



Aalto University  
School of Chemical  
Engineering

# ALD, MLD & ALD/MLD

**Maarit KARPPINEN**

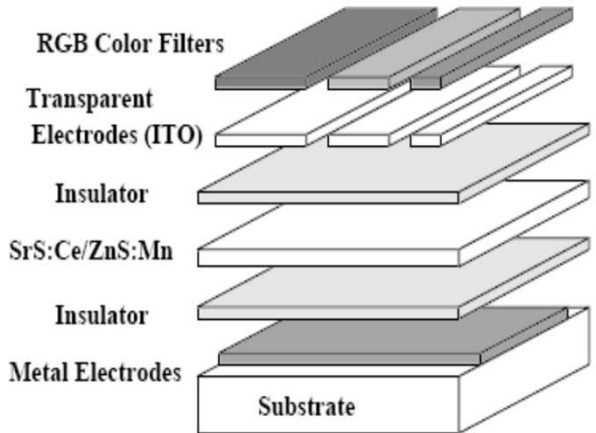
*Inorganic Materials Chemistry  
Department of Chemistry & Materials Science  
Aalto University*

Surfaces & Films

4.11.2020

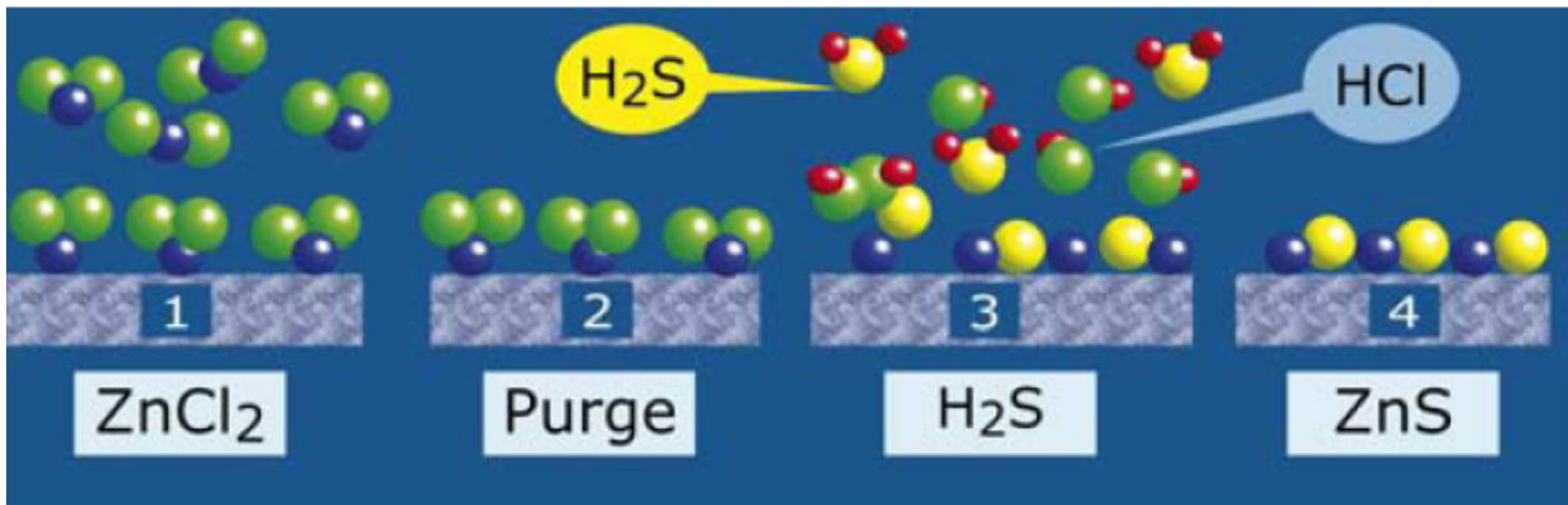
# Atomic Layer Deposition (ALD) Thin-Film Technique

- Gaseous precursors
- Self-limiting surface reactions
- Conformal, homogeneous thin films with atomic-layer accuracy



Electroluminescent display

Instrumentarium/Finlux /Planar



# Prototype ALD thin films

- ALD- $\text{Al}_2\text{O}_3$  (amorphous): barrier and protective coating
- ALD- $\text{HfO}_2$  (amorphous): high-k dielectrics
- ALD- $\text{ZnO}$  (crystalline): semiconductor (e.g. thermoelectrics)
- ALD- $\text{TiO}_2$  (crystalline): e.g. photovoltaics

# Atomic Layer Deposition of $\text{Al}_2\text{O}_3$ ( $\text{AlO}_x$ )

- Al-source (precursor):  $\text{Al}(\text{CH}_3)_3$
- Oxygen source (co-reactant):  $\text{H}_2\text{O}$
- Substrate: Si

- (1) Substrate surface is initially covered with hydroxyl (OH) groups

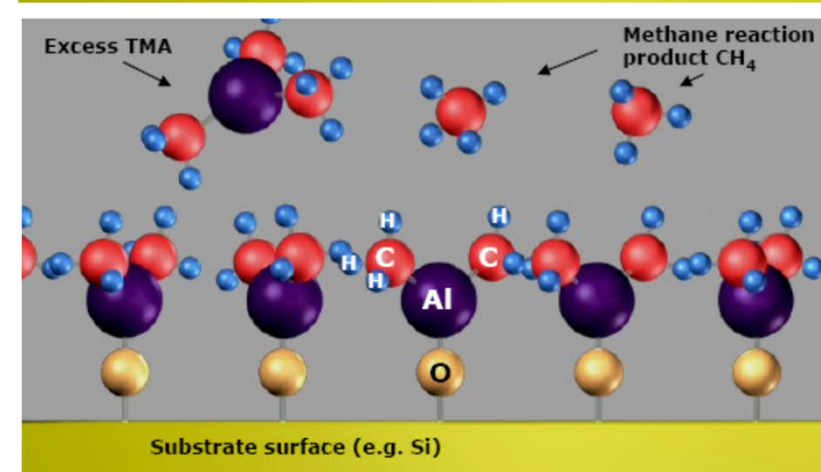
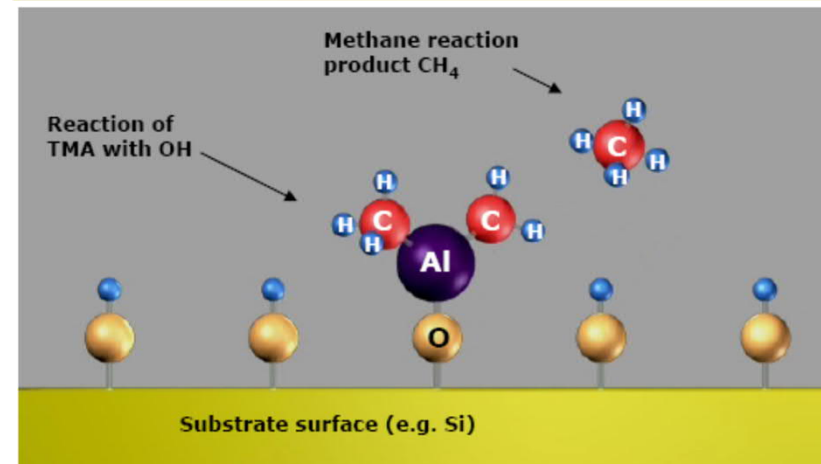
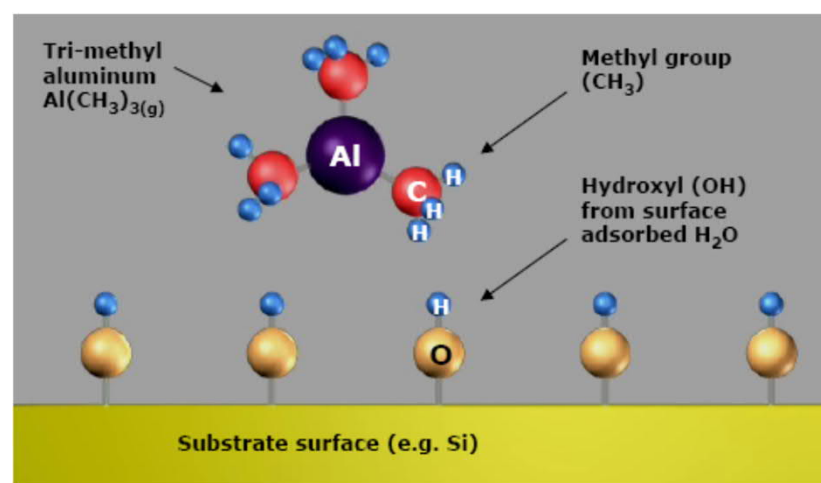
First trimethyl aluminum [TMA:  $\text{Al}(\text{CH}_3)_3$ ] is pulsed into the reactor

- (2) TMA reacts with the surface OH groups, producing methane ( $\text{CH}_4$ ) as a byproduct

- (3) Reaction continues until the surface is passivated (= covered with a TMA layer)

TMA does not react with itself: this terminates the reaction to one layer

Excess TMA and methane molecules are pumped away (purged with an  $\text{N}_2$  pulse)



(4) Next, water vapour ( $\text{H}_2\text{O}$ ) is pulsed into the reaction chamber

(5) Water reacts with the surface methyl ( $\text{CH}_3$ ) groups, forming Al-O bonds and surface OH groups

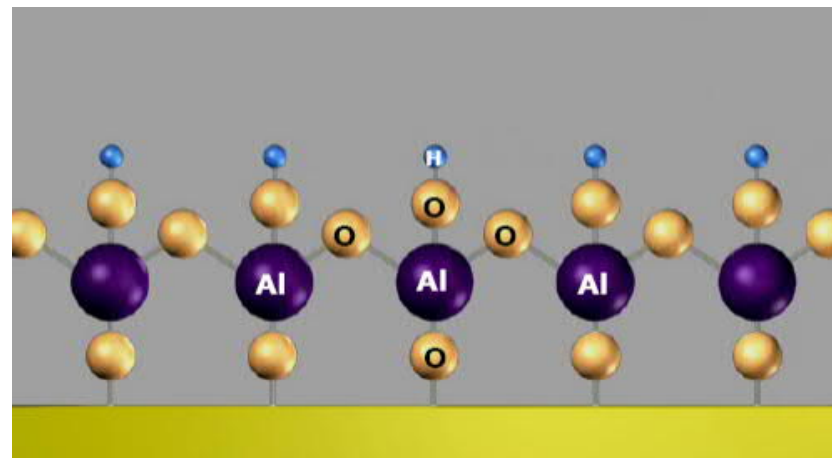
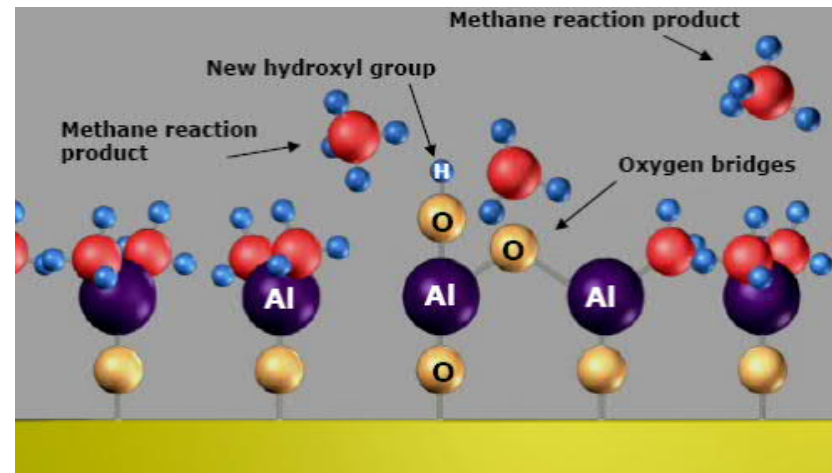
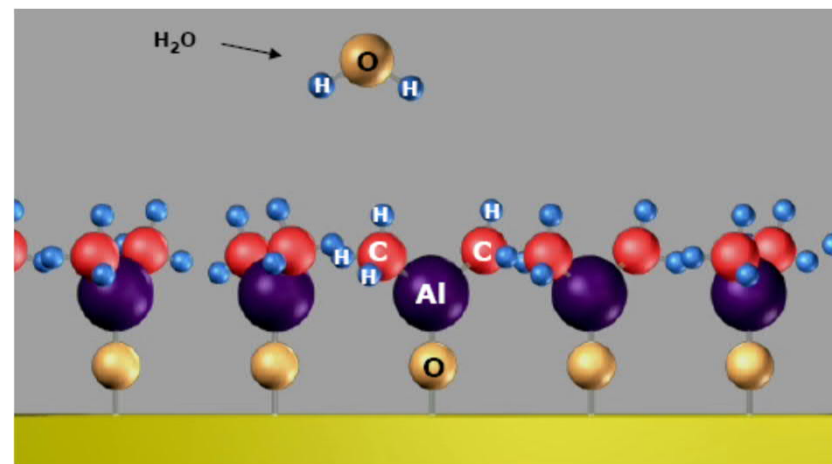
Again methane is the byproduct

Reaction continues until the surface is passivated

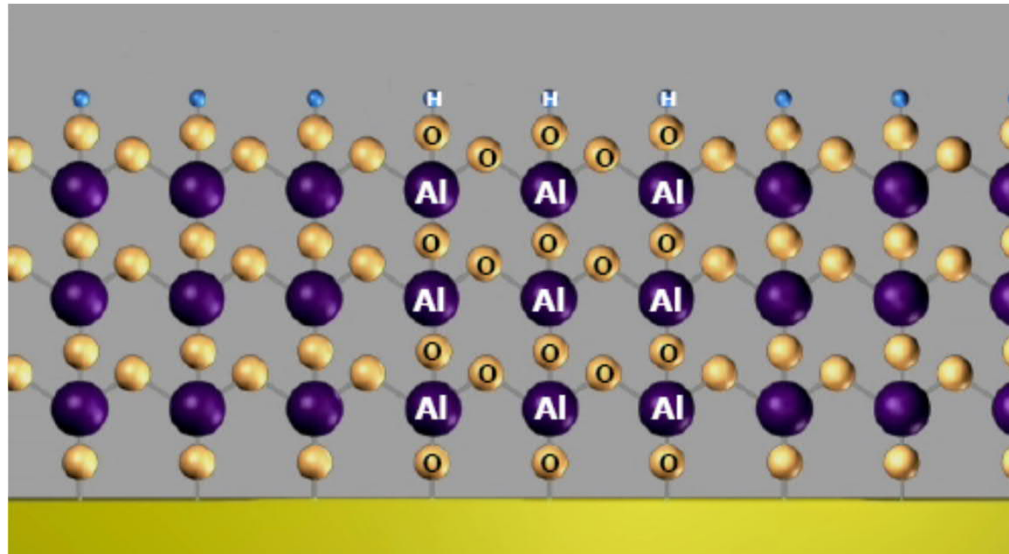
Again the reaction is self-limited to one new layer

(as  $\text{H}_2\text{O}$  does not react with itself)

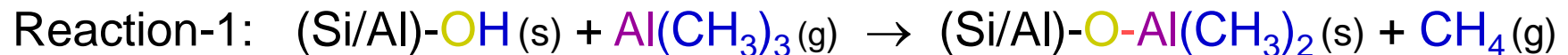
(6) Excess  $\text{H}_2\text{O}$  and  $\text{CH}_4$  molecules are pumped away (purged with an  $\text{N}_2$  pulse)



- One TMA pulse (+ N<sub>2</sub> purge) and one H<sub>2</sub>O pulse (+ N<sub>2</sub> purge) form one ALD cycle, producing one layer of Al<sub>2</sub>O<sub>3</sub> (of ca. 1 Å in thickness)
- Here the outcome of three ideal ALD cycles is shown
- Each cycle takes approximately 5 to 10 seconds

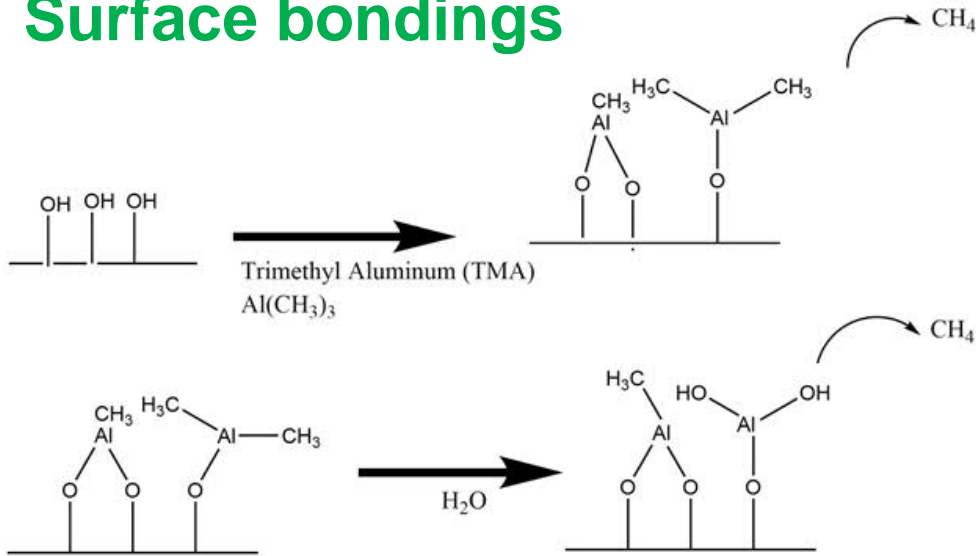


www.cambridgenanotech.com

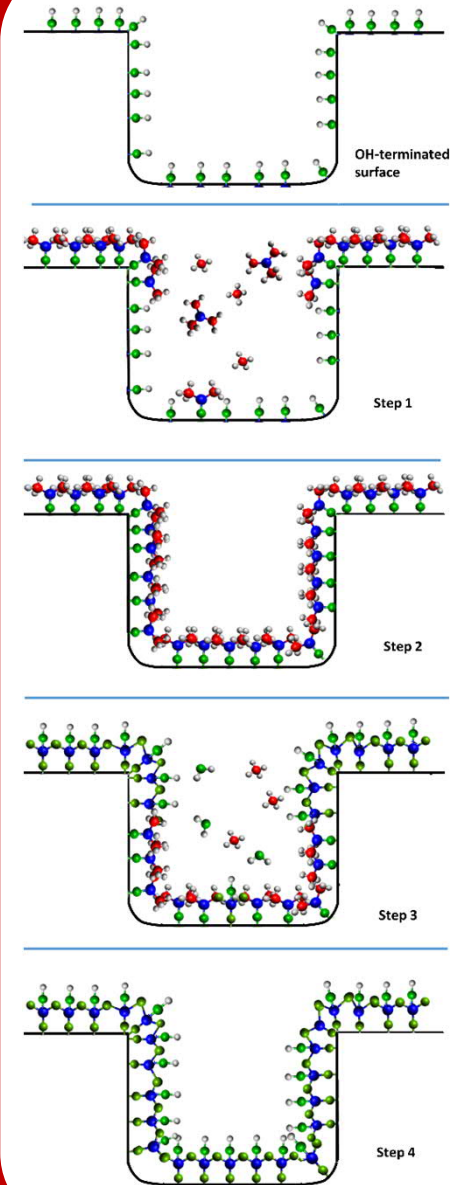




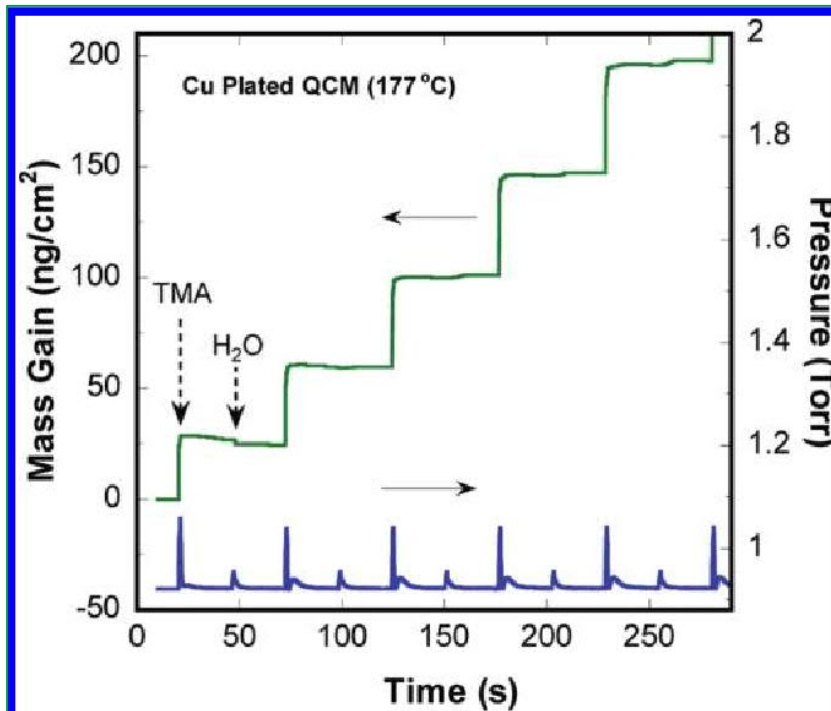
# Surface bondings



# Conformal coating



**In-situ QCM**  
(quartz crystal microbalance)



**Kalevala Koru  
(Finland):**

**- traditional  
silver  
jewelry**



**Beneq (Finland):  
- Al<sub>2</sub>O<sub>3</sub> coating by ALD**



**uncoated**



**Al<sub>2</sub>O<sub>3</sub>-coated**



**BEFORE**

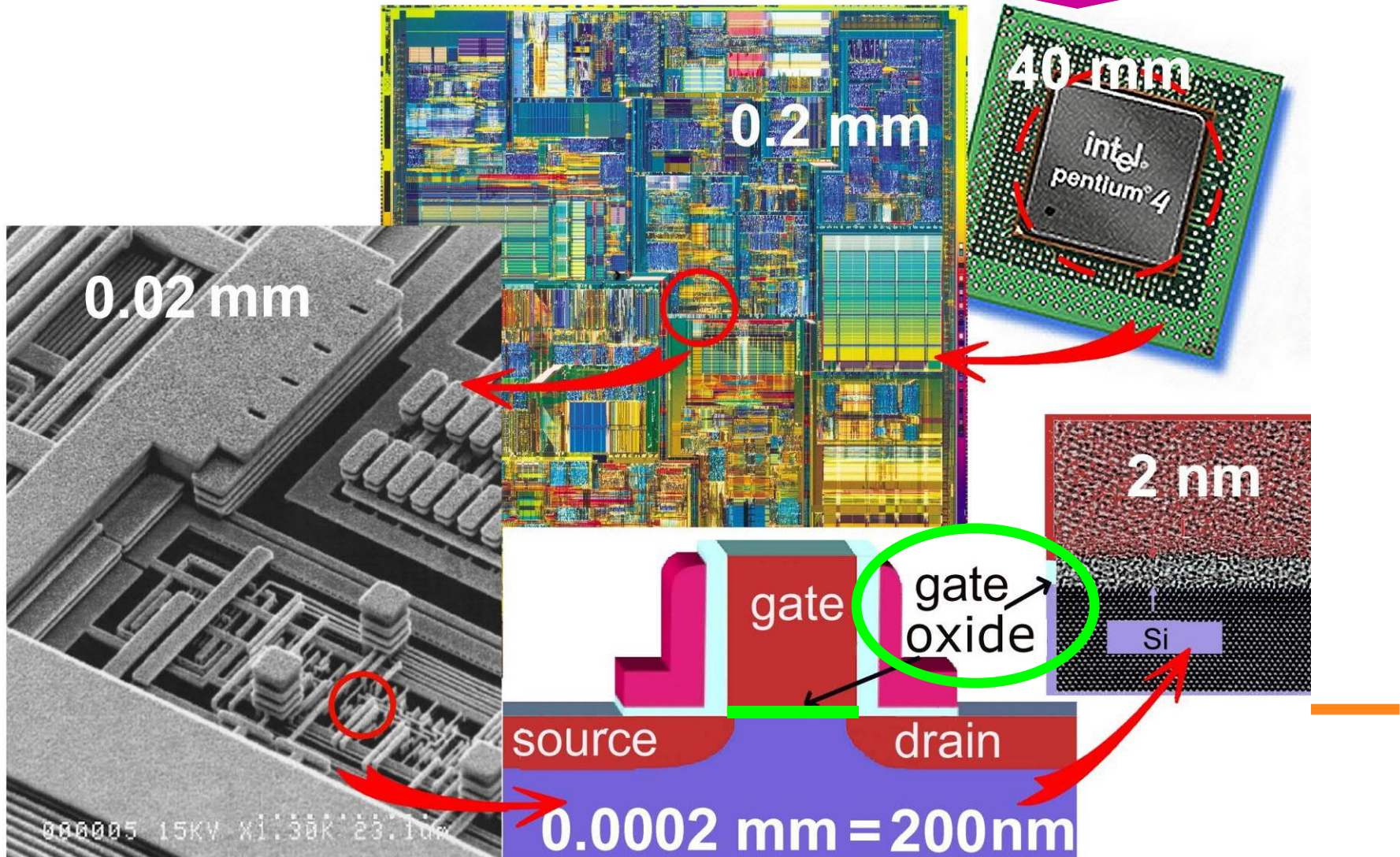
**AFTER TARNISHING TEST**

**Dense, pinhole-free  
& highly **conformal**  
ALD-Al<sub>2</sub>O<sub>3</sub>-nanocoating  
efficiently protects  
silver jewelries  
from tarnishing**



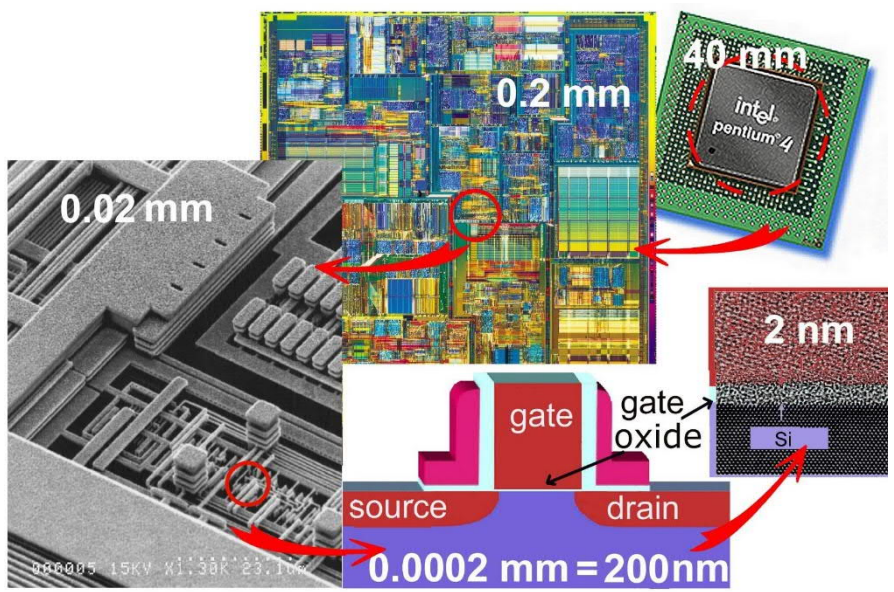
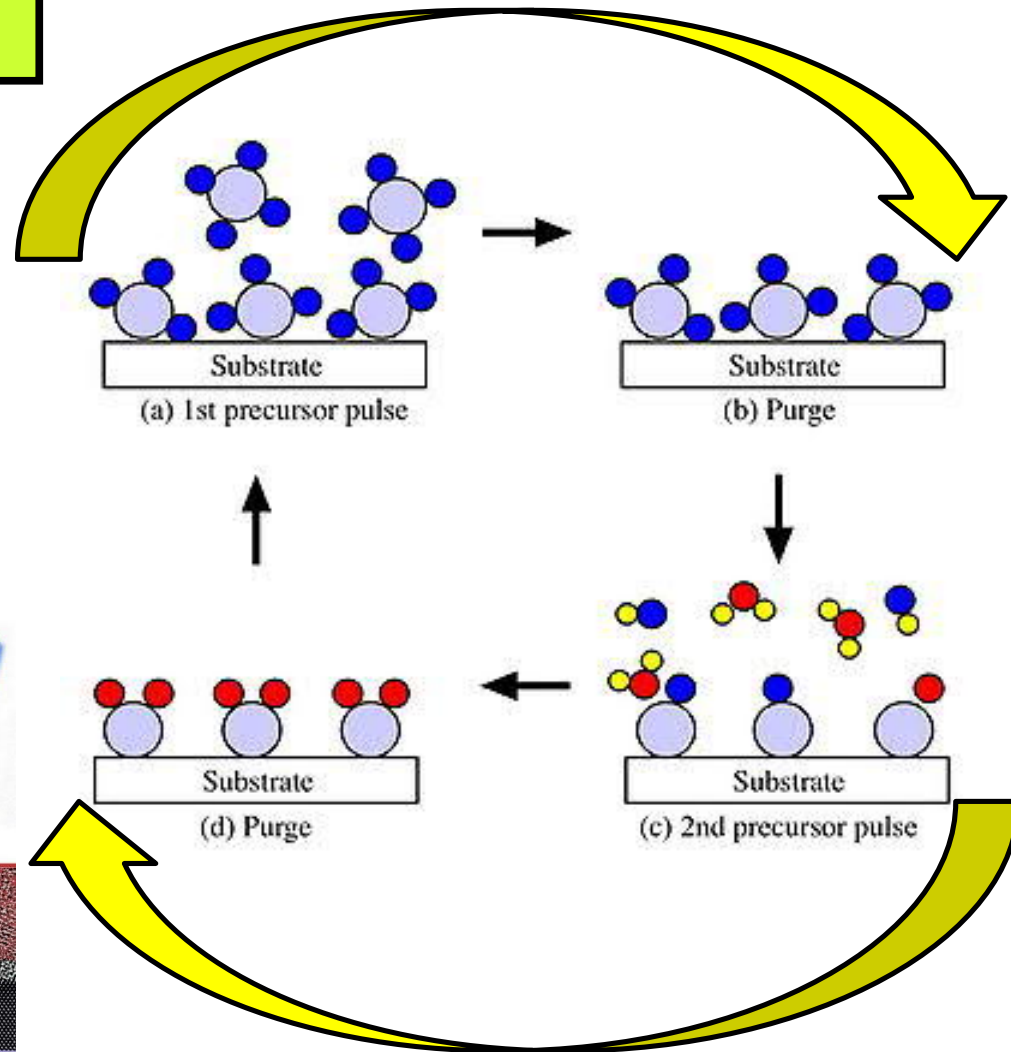
# CMOS transistor

smaller transistors → lower gate voltage  
same electric fields → thinner dielectric  
SiO<sub>2</sub> → **HIGH-k DIELECTRICS**

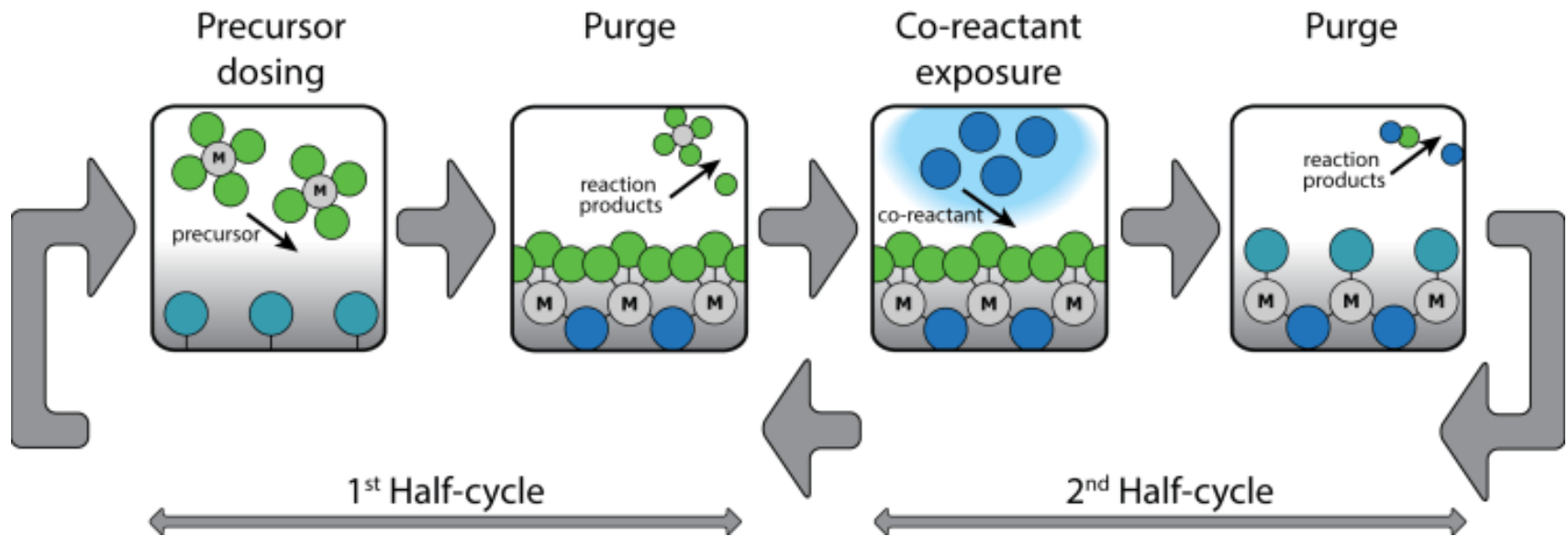
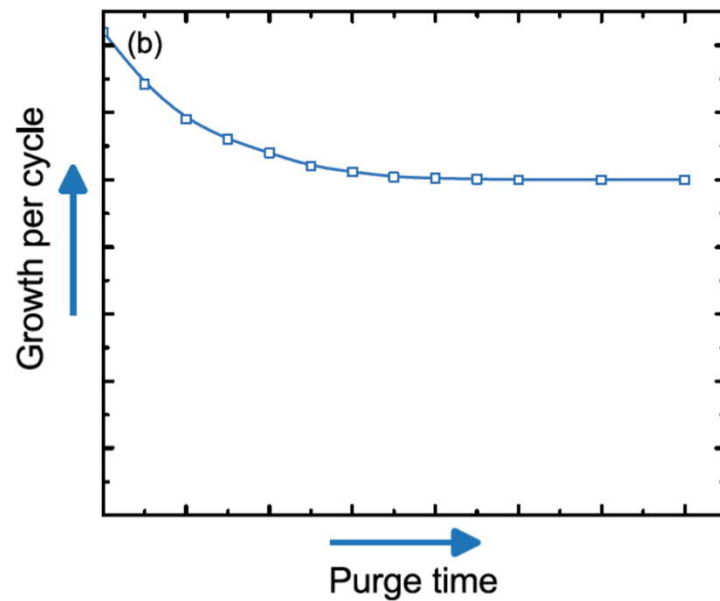
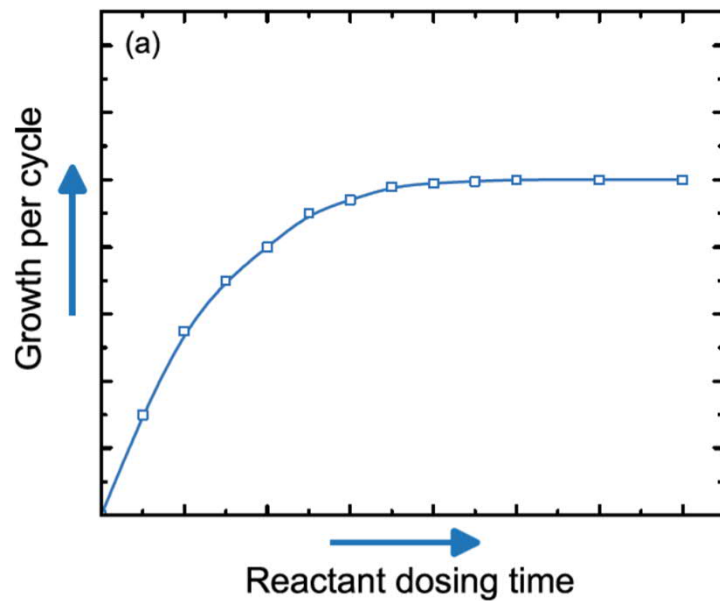


# HfO<sub>2</sub>-ALD gate oxide HfCl<sub>4</sub> + H<sub>2</sub>O

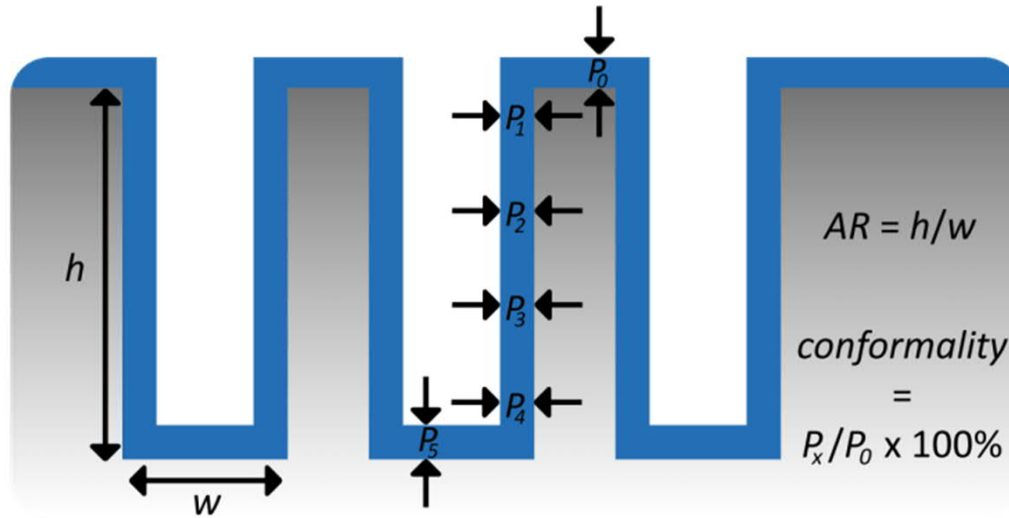
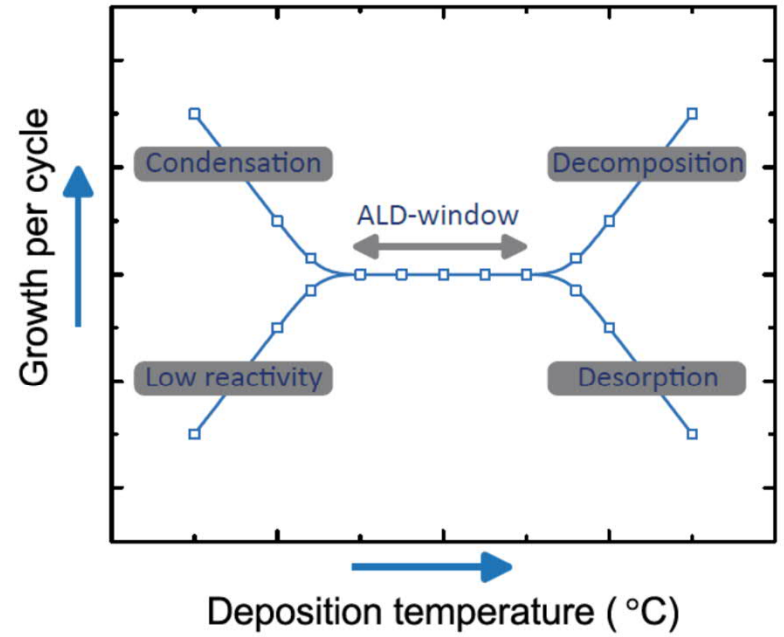
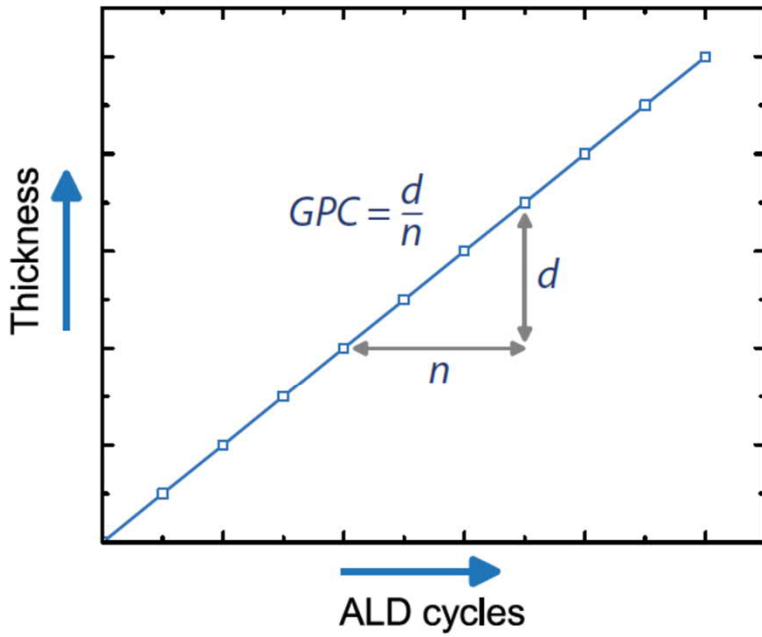
## ALD cycle



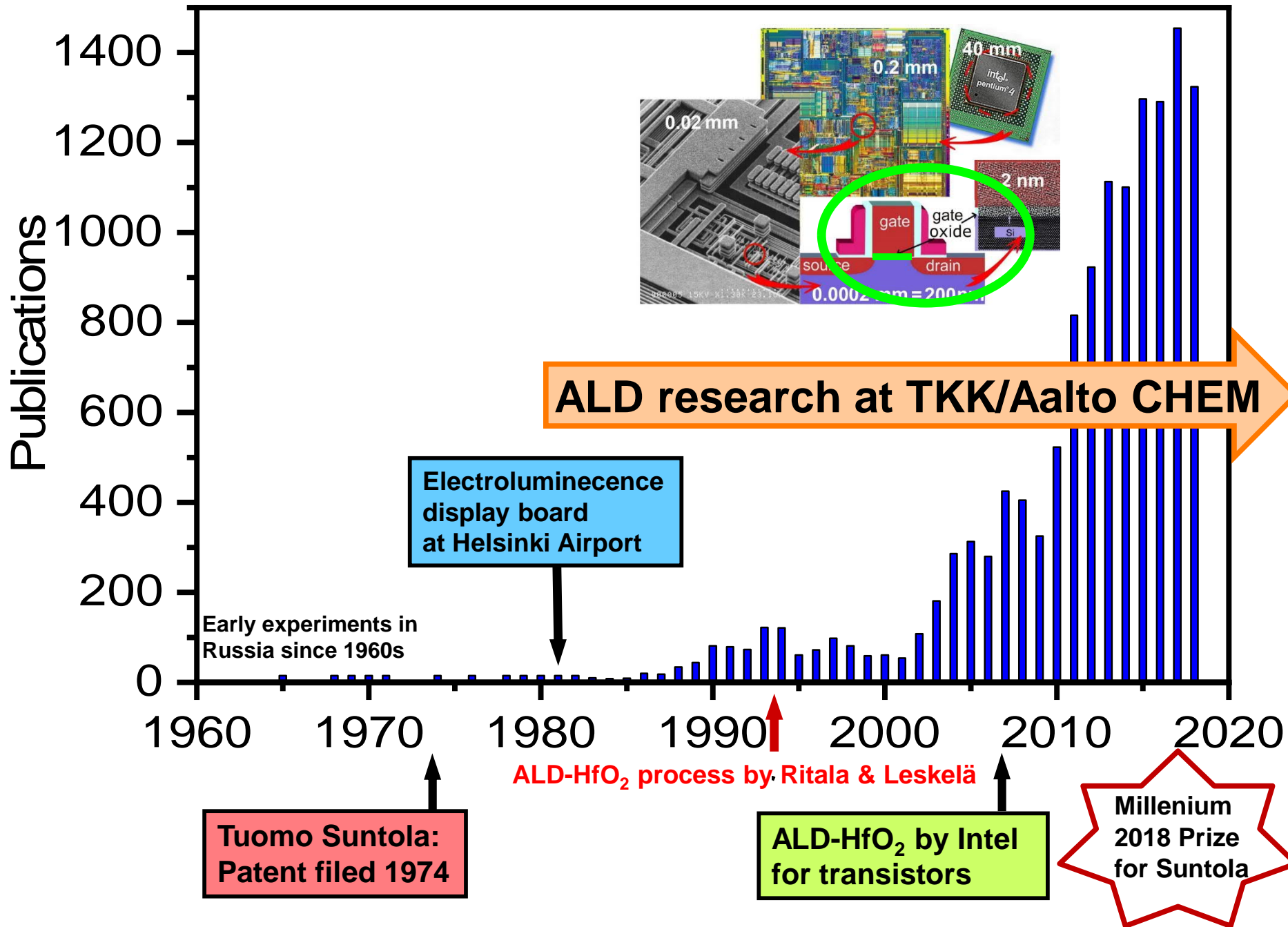




**FILM GROWTH RATE: Growth per Cycle (GPC) [ $\text{\AA}/\text{cycle}$ ]**



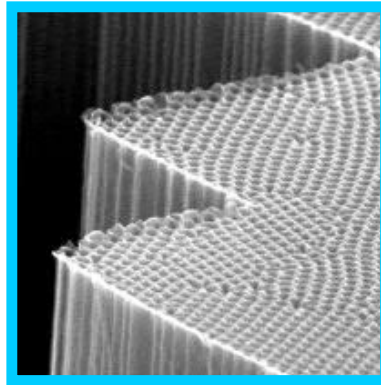
# Atomic Layer Deposition (ALD)





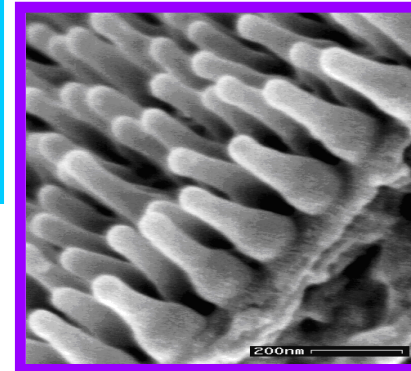
# Advantages of ALD

- Relatively inexpensive method
- Excellent repeatability
- Dense and pinhole-free films
- Accurate and simple thickness control
- Large area uniformity
- Easy doping
- Excellent conformality
- Low deposition temperature
- Gentle deposition process
- Organic/polymer films
- Inorganic/organic hybrid materials



ELECTRONICS

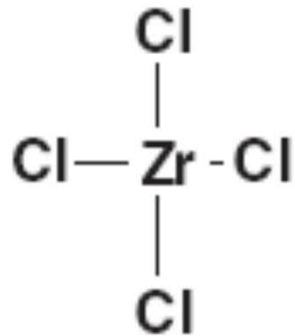
NANO



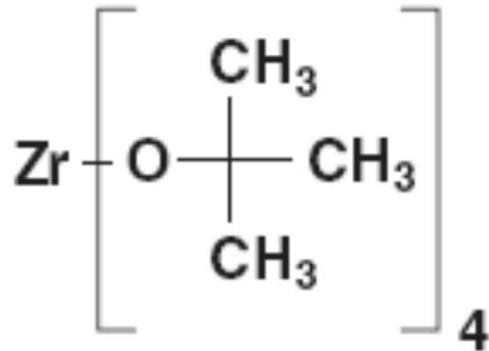
BIO

NEW

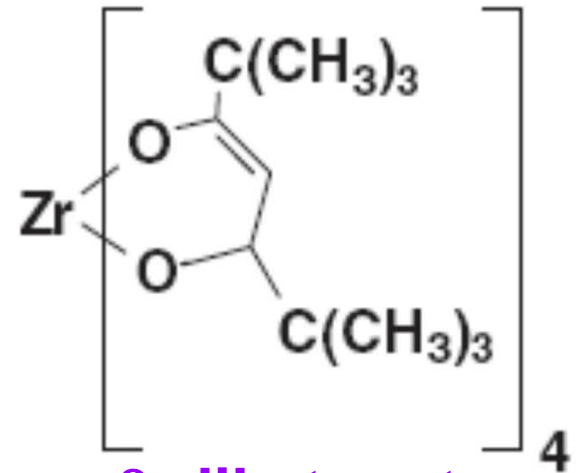
# COMMON METAL PRECURSORS in ALD



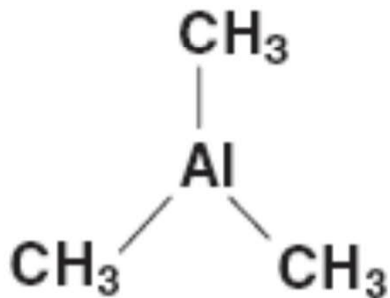
halides



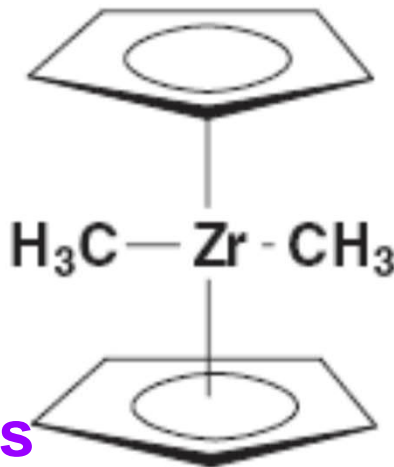
alkoxides



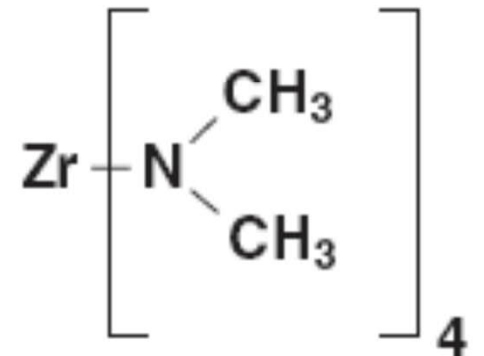
$\beta$ -diketonates



organometallics



e.g. cyclopentadienyls

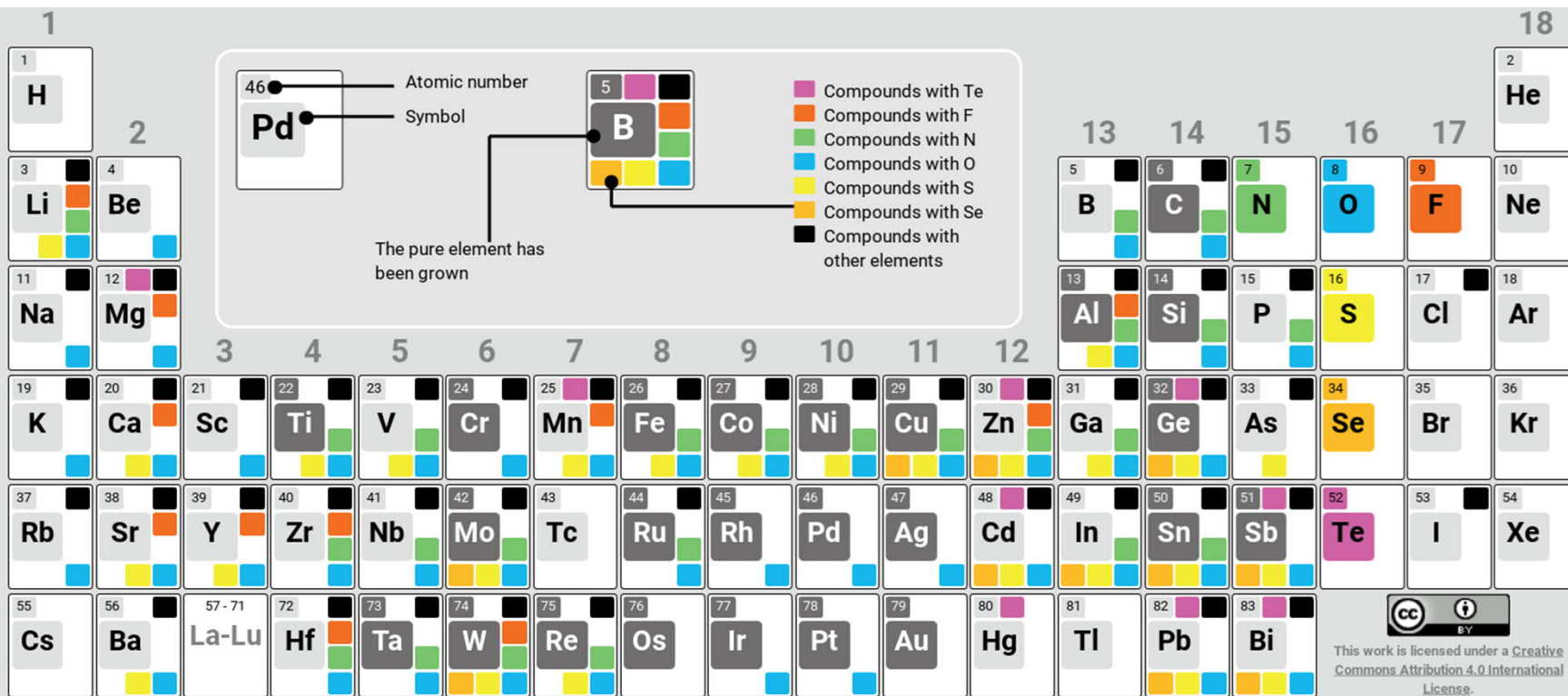


amido complexes

# ALD precursors tested at HUT

GROUP		ALD precursors tested at HUT																VIII																				
IA																																						
1	1	<b>H</b> Hydrogen 1.00794																	2	<b>He</b> Helium 4.00260																		
2	3	<b>Li</b> Lithium 6.941	4	<b>Be</b> Beryllium 9.01218																	5	<b>B</b> Boron 10.811	6	<b>C</b> Carbon 12.0107	7	<b>N</b> Nitrogen 14.00674	8	<b>O</b> Oxygen 15.9994	9	<b>F</b> Fluorine 18.99840	10	<b>Ne</b> Neon 20.1797						
3	11	<b>Na</b> Sodium 22.98977	12	<b>Mg</b> Magnesium 24.304																	13	<b>Al</b> Aluminum 26.98154	14	<b>Si</b> Silicon 28.086	15	<b>P</b> Phosphorus 30.97376	16	<b>S</b> Sulfur 32.066	17	<b>Cl</b> Chlorine 35.4527	18	<b>Ar</b> Argon 39.948						
PERIOD	4	19	<b>K</b> Potassium 39.0983	20	<b>Ca</b> Calcium 40.078	21	<b>Sc</b> Scandium 44.95591	22	<b>Ti</b> Titanium 47.867	23	<b>V</b> Vanadium 50.9415	24	<b>Cr</b> Chromium 51.9961	25	<b>Mn</b> Manganese 54.93805	26	<b>Fe</b> Iron 55.845	27	<b>Co</b> Cobalt 58.93320	28	<b>Ni</b> Nickel 58.6934	29	<b>Cu</b> Copper 63.546	30	<b>Zn</b> Zinc 65.39	31	<b>Ga</b> Gallium 69.723	32	<b>Ge</b> Germanium 72.61	33	<b>As</b> Arsenic 74.92160	34	<b>Se</b> Selenium 78.96	35	<b>Br</b> Bromine 79.904	36	<b>Kr</b> Krypton 83.80	
	5	37	<b>Rb</b> Rubidium 85.4678	38	<b>Sr</b> Strontium 87.62	39	<b>Y</b> Yttrium 88.90585	40	<b>Zr</b> Zirconium 91.224	41	<b>Nb</b> Niobium 92.90638	42	<b>Mo</b> Molybdenum 95.94	43	<b>Tc</b> Technetium (98)	44	<b>Ru</b> Ruthenium 101.07	45	<b>Rh</b> Rhodium 102.90550	46	<b>Pd</b> Palladium 106.42	47	<b>Ag</b> Silver 107.8682	48	<b>Cd</b> Cadmium 112.411	49	<b>In</b> Indium 114.818	50	<b>Sn</b> Tin 118.710	51	<b>Sb</b> Antimony 121.760	52	<b>Te</b> Tellurium 127.60	53	<b>I</b> Iodine 126.90447	54	<b>Xe</b> Xenon 131.29	
	6	55	<b>Cs</b> Cesium 132.90545	56	<b>Ba</b> Barium 137.327	72	<b>Hf</b> Hafnium 178.49	73	<b>Ta</b> Tantalum 180.94788	74	<b>W</b> Tungsten 183.84	75	<b>Re</b> Rhenium 186.207	76	<b>Os</b> Osmium 190.23	77	<b>Ir</b> Iridium 192.217	78	<b>Pt</b> Platinum 195.078	79	<b>Au</b> Gold 196.96655	80	<b>Hg</b> Mercury 200.59	81	<b>Tl</b> Thallium 204.3833	82	<b>Pb</b> Lead 207.2	83	<b>Bi</b> Bismuth 208.9804	84	<b>Po</b> Polonium (209)	85	<b>At</b> Astatine (210)	86	<b>Rn</b> Radon (222)			
	7	87	<b>Fr</b> Francium (223)	88	<b>Ra</b> Radium (226)	104	<b>Rf</b> Rutherfordium (261)	105	<b>Db</b> Dubnium (262)	106	<b>Sg</b> Seaborgium (263)	107	<b>Bh</b> Bohrium (264)	108	<b>Hs</b> Hassium (265)	109	<b>Mt</b> Meitnerium (268)	110	<b>Uun</b> Ununnilium (269)	111	<b>Uuu</b> Ununnilium (272)	112	<b>Uub</b> Ununbium (277)															
			57	<b>La</b> Lanthanum 138.90547	58	<b>Ce</b> Cerium 140.12	59	<b>Pr</b> Praseodymium 140.90766	60	<b>Nd</b> Neodymium 144.242	61	<b>Pm</b> Promethium (145)	62	<b>Sm</b> Samarium 150.36	63	<b>Eu</b> Europium 151.964	64	<b>Gd</b> Gadolinium 157.25	65	<b>Tb</b> Terbium 158.92534	66	<b>Dy</b> Dysprosium 162.50	67	<b>Ho</b> Holmium 164.93032	68	<b>Er</b> Erbium 167.259	69	<b>Tm</b> Thulium 168.93421	70	<b>Yb</b> Ytterbium 173.04	71	<b>Lu</b> Lutetium 174.967						
			89	<b>Ac</b> Actinium (227)	90	<b>Th</b> Thorium 232.0381	91	<b>Pa</b> Protactinium 231.03688	92	<b>U</b> Uranium 238.02891	93	<b>Np</b> Neptunium (237)	94	<b>Pu</b> Plutonium (244)	95	<b>Am</b> Americium (243)	96	<b>Cm</b> Curium (247)	97	<b>Bk</b> Berkelium (247)	98	<b>Cf</b> Californium (251)	99	<b>Es</b> Einsteinium (252)	100	<b>Fm</b> Fermium (257)	101	<b>Md</b> Mendelevium (258)	102	<b>No</b> Nobelium (259)	103	<b>Lr</b> Lawrencium (262)						

<span style="display: inline-block; width: 15px; height: 15px; background-color: yellow; border: 1px solid black;"></span> Halides
<span style="display: inline-block; width: 15px; height: 15px; background-color: magenta; border: 1px solid black;"></span> b- diketonates
<span style="display: inline-block; width: 15px; height: 15px; background-color: cyan; border: 1px solid black;"></span> Organometallics
<span style="display: inline-block; width: 15px; height: 15px; background-color: green; border: 1px solid black;"></span> Other



Lanthanoids

www.AtomicLimits.com - DOI: [10.6100/alddbbase](https://doi.org/10.6100/alddbbase)

## COMMON CO-REACTANTS (second precursor) in ALD

- Water  $\text{H}_2\text{O}$  (e.g. with  $\text{TiCl}_4$ ,  $\text{Al}(\text{CH}_3)_3$  or  $\text{Zn}(\text{CH}_2\text{CH}_3)_2$ ) → Oxides
- Ozone  $\text{O}_3$  (e.g. with metal  $\beta$ -diketonates) → Oxides
- Dihydrogensulfide  $\text{H}_2\text{S}$  (e.g. with  $\text{ZnCl}_2$ ) → Sulfides
- Ammonia  $\text{NH}_3$  → Nitrides

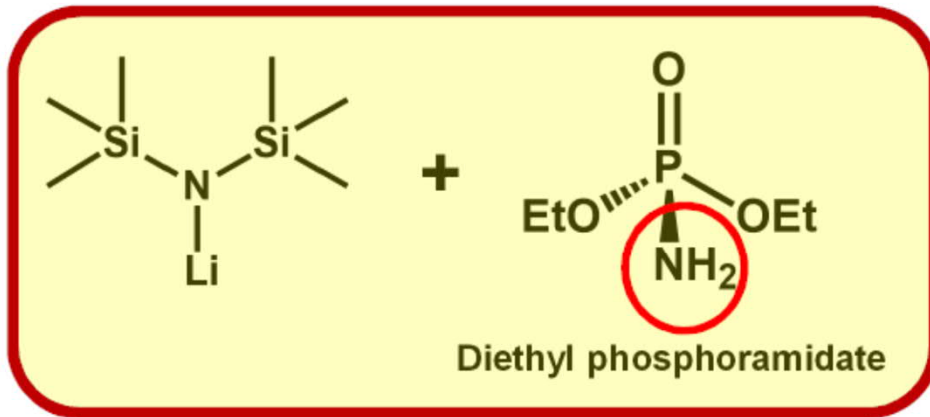




# LIPON BY ALD WITH



- Lithium phosphorous oxynitride  $\text{Li}_x\text{PO}_y\text{N}_z$
- A promising solid-state electrolyte for thin-film Li-ion microbattery

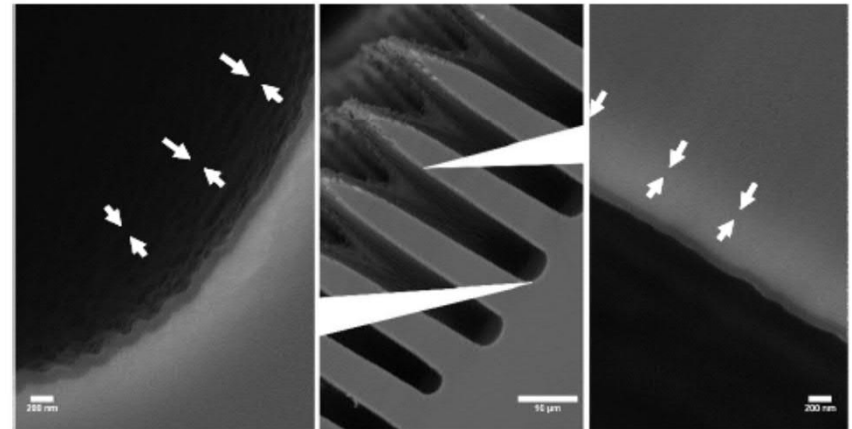


RBS-NRA

$\text{Li}_{0.94}\text{PO}_{3.00}\text{N}_{0.60}$

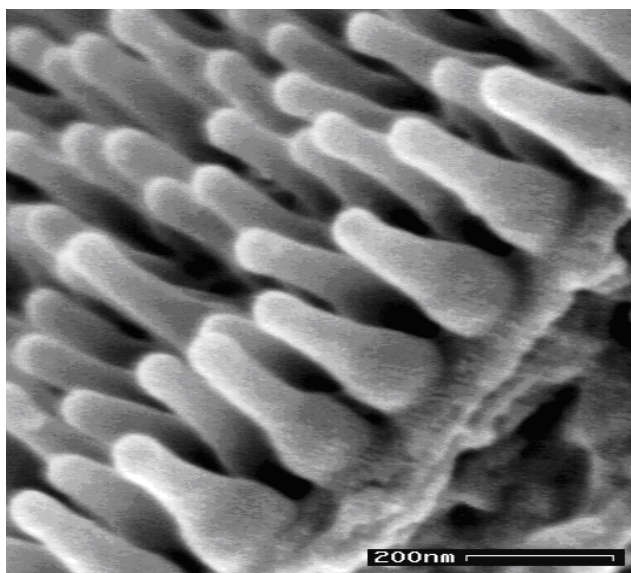
Ionic cond.

$7 \times 10^{-7} \text{ S cm}^{-1}$



M. Nisula, Y. Shindo, H. Koga & M. Karppinen,  
*Chem. Mater.* **27**, 6987 (2015).





## CICADA WING

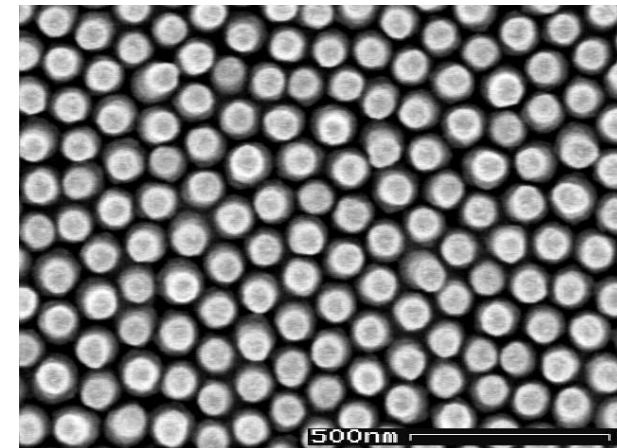
- Peculiar surface-nanostructure  
200-nm high nanopillars with a **WAXY SURFACE**
- **superhydrofobic**

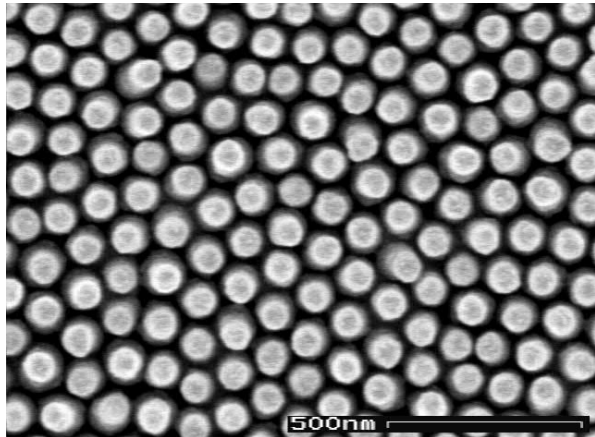
## ZnO

- **Reversible change** from hydrofobic to hydrophilic upon UV-radiation

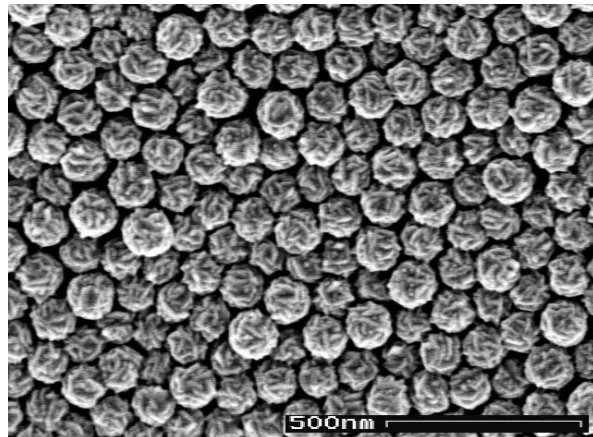
## CICADA WING + ZnO (+ few-nm Al<sub>2</sub>O<sub>3</sub>)

- Conformal coating of the **wing** by a thin layer of **ZnO** (~20 nm) by means of **ALD**
- **Reversible change** from **superhydrofobic** to **superhydrophilic** upon UV-radiation

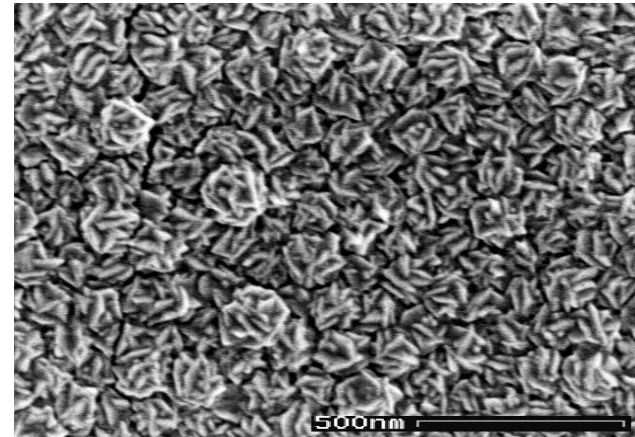




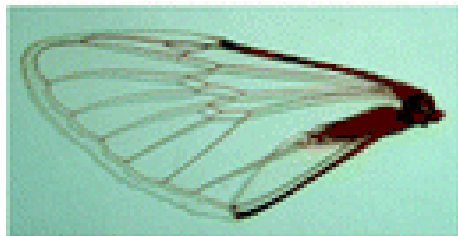
100 cycles (20 nm)



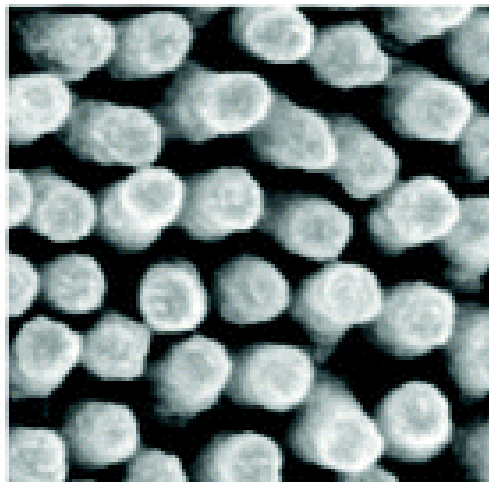
300 cycles (60 nm)



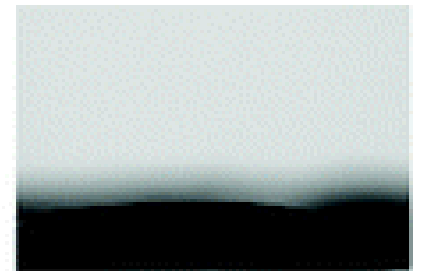
500 cycles (100 nm)



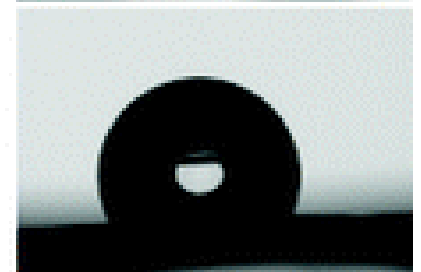
ALD  
→



UV  
→



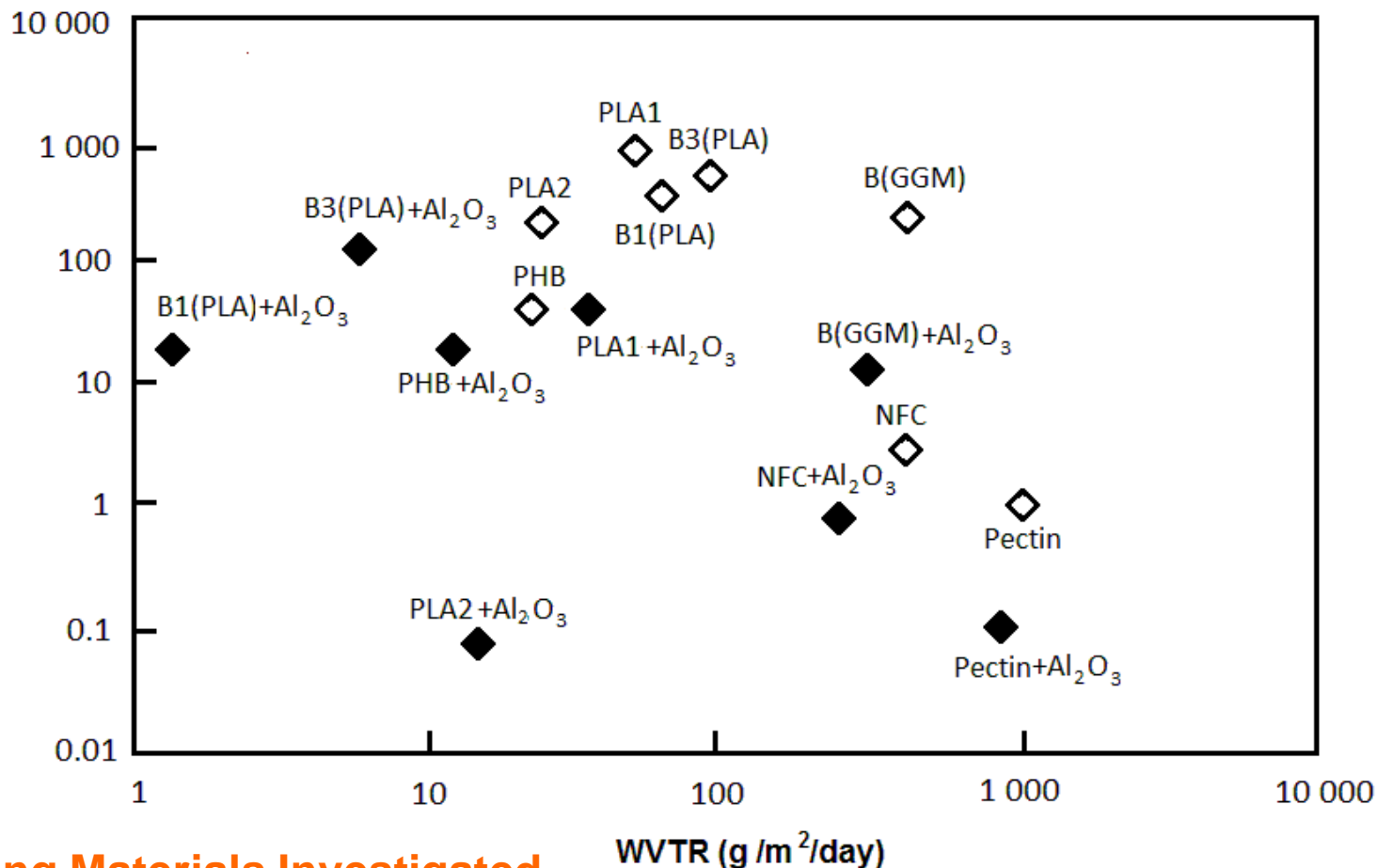
dark  
→



# RECYCLABLE BIO-BASED PACKAGING MATERIALS

*Problem:  
Bad  
gas-  
barriers*

OTR ( $\text{cm}^3/\text{m}^2/10^5 \text{ Pa/day}$ )



## Bio-based Packaging Materials Investigated

B(PLA)	Poly lactide-coated board
PLA	Poly lactide film
NFC	Nano-fibrillated cellulose film
B(GGM)	Galactoclugomannan-coated board
PHB	Polyhydroxy butyrate film
Pectin	Pectin film made by solution casting

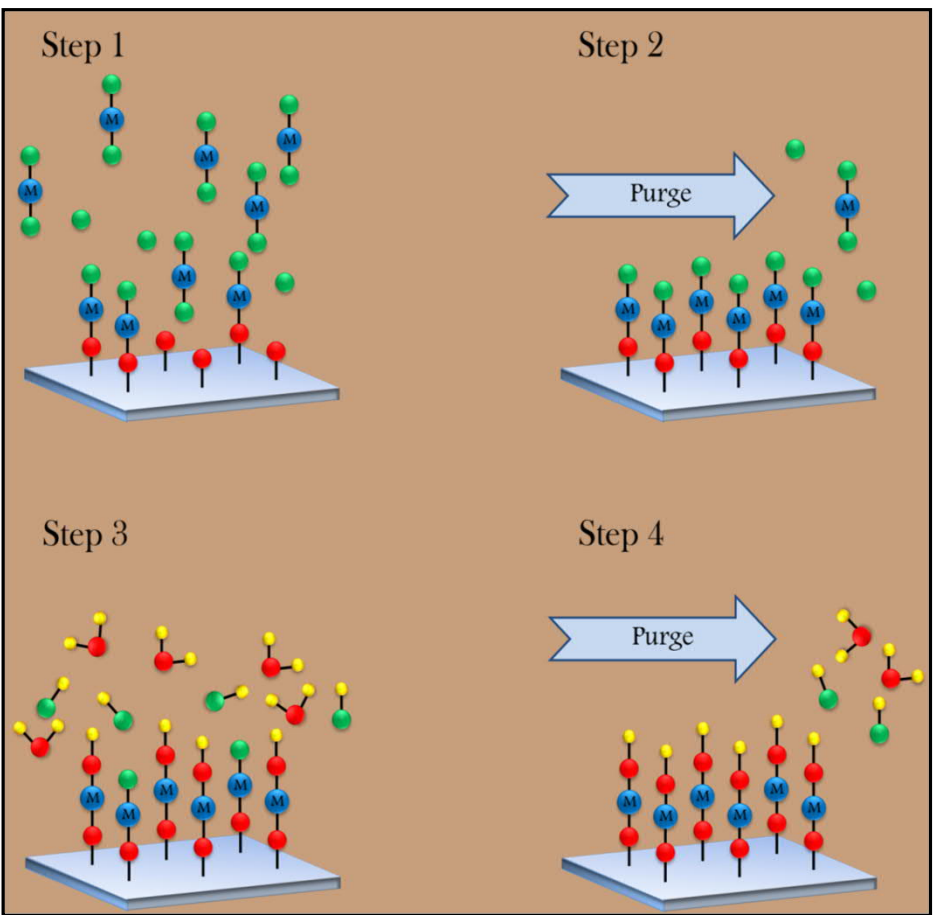
## O<sub>2</sub>- and H<sub>2</sub>O-vapour transmission

◇ Biopolymer

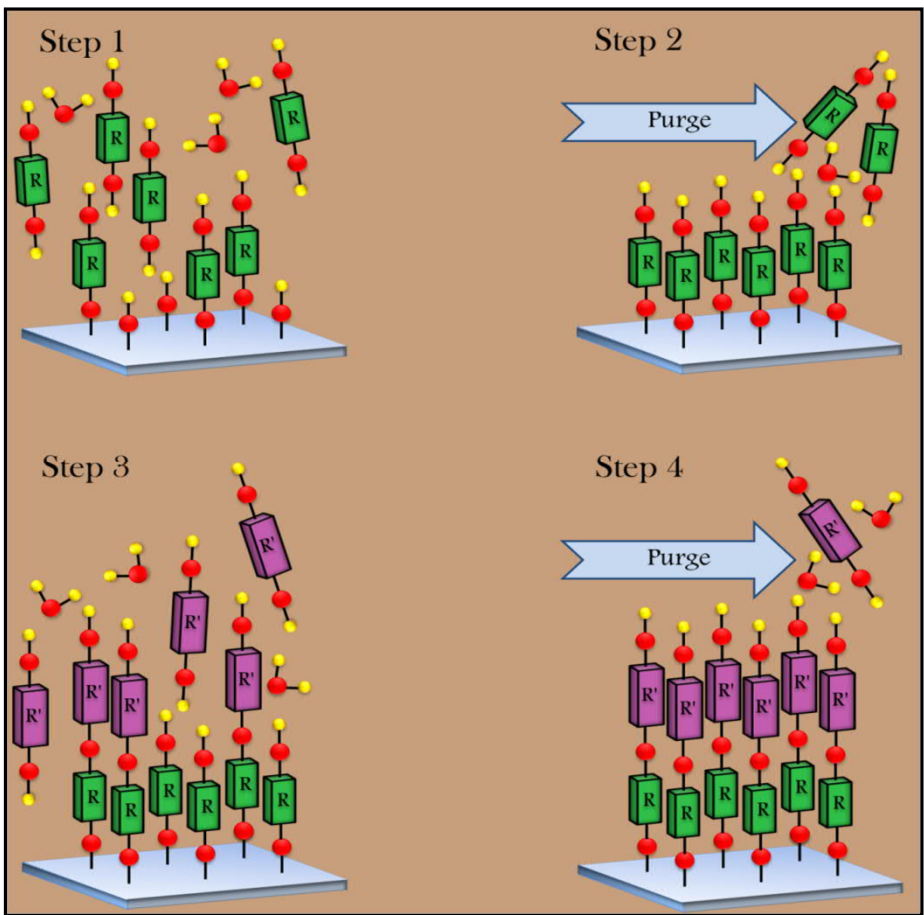
◆ Biopolymer + 25 nm ALD-Al<sub>2</sub>O<sub>3</sub>

T. Hirvikorpi, M. Vähä-Nissi, J. Nikkola,  
A. Harlin & M. Karppinen,  
*Surf. Coat. Technol.* 205, 5088 (2011).





**ALD** (Atomic Layer Deposition)

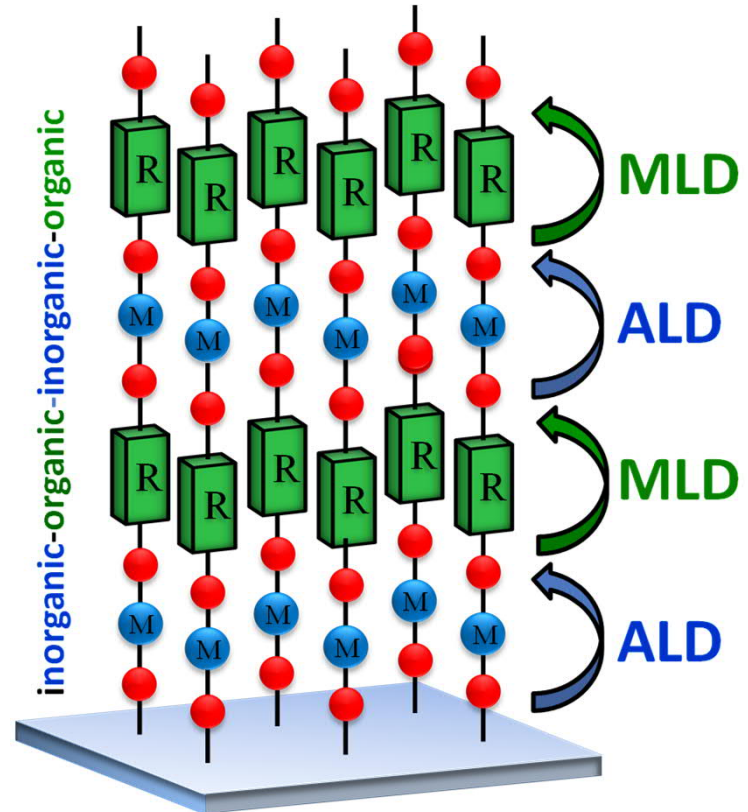
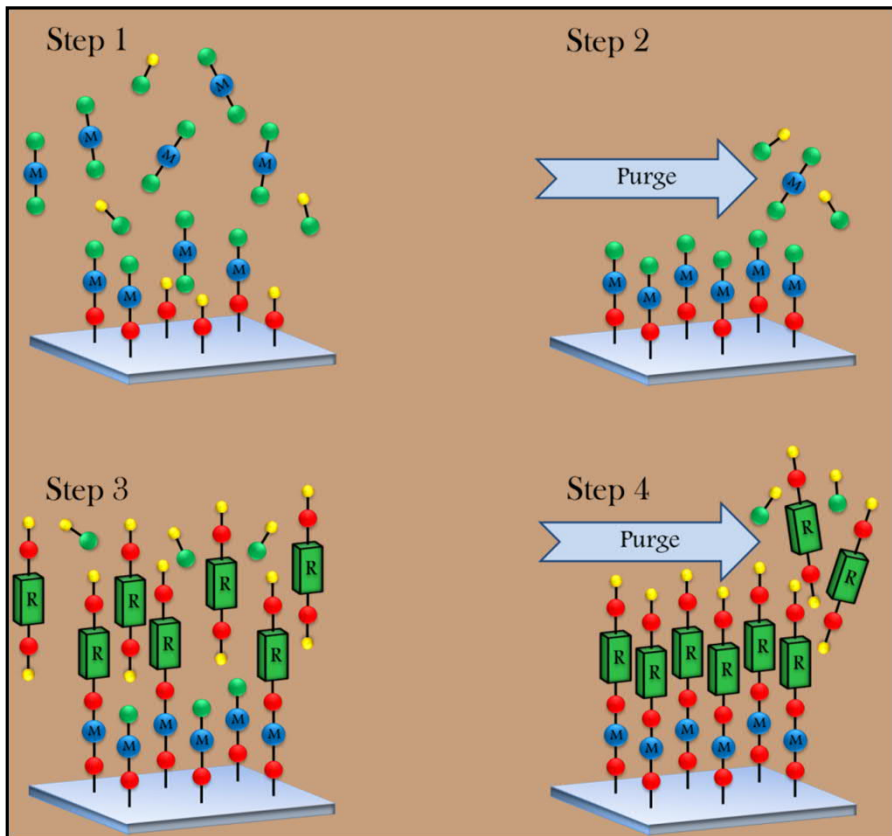


**MLD** (Molecular Layer Deposition)

High-quality  
**INORGANIC** thin films  
 with atomic level control

**ORGANICS!**

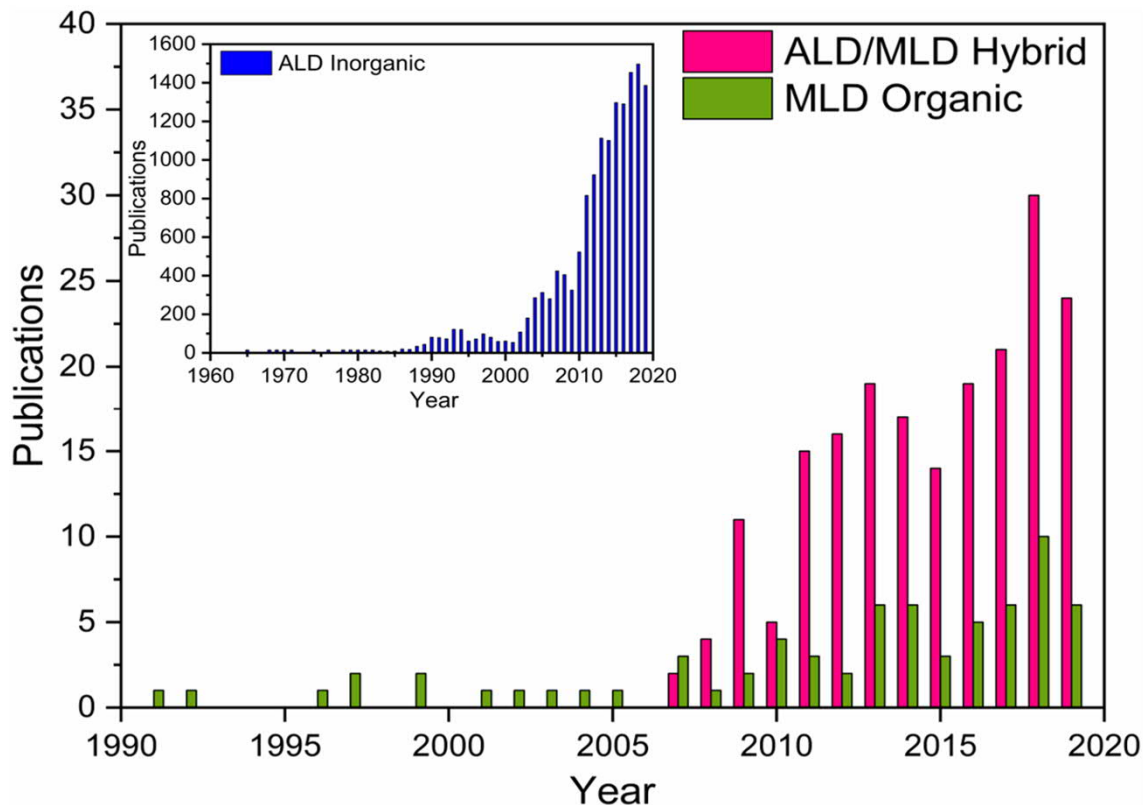
# Inorganic-Organic (Metal-Organic) Hybrid Thin Films by Combined ALD/MLD



**FLEXIBLE MULTIFUNCTIONAL SINGLE-PHASE HYBRID MATERIALS !!!**

# ANNUALLY PUBLISHED PAPERS:

## MLD & ALD/MLD



Yoshimura, Tatsuura & Sotoyama, *Appl. Phys. Lett.* **1991**, 59, 482.

Yoshimura, Tatsuura, Sotoyama, Matsuura & Hayano, *Appl. Phys. Lett.* **1992**, 60, 268.

Kubono, Yuasa, Shao, Umemoto & Okui, *Thin Solid Films* **1996**, 289, 107.

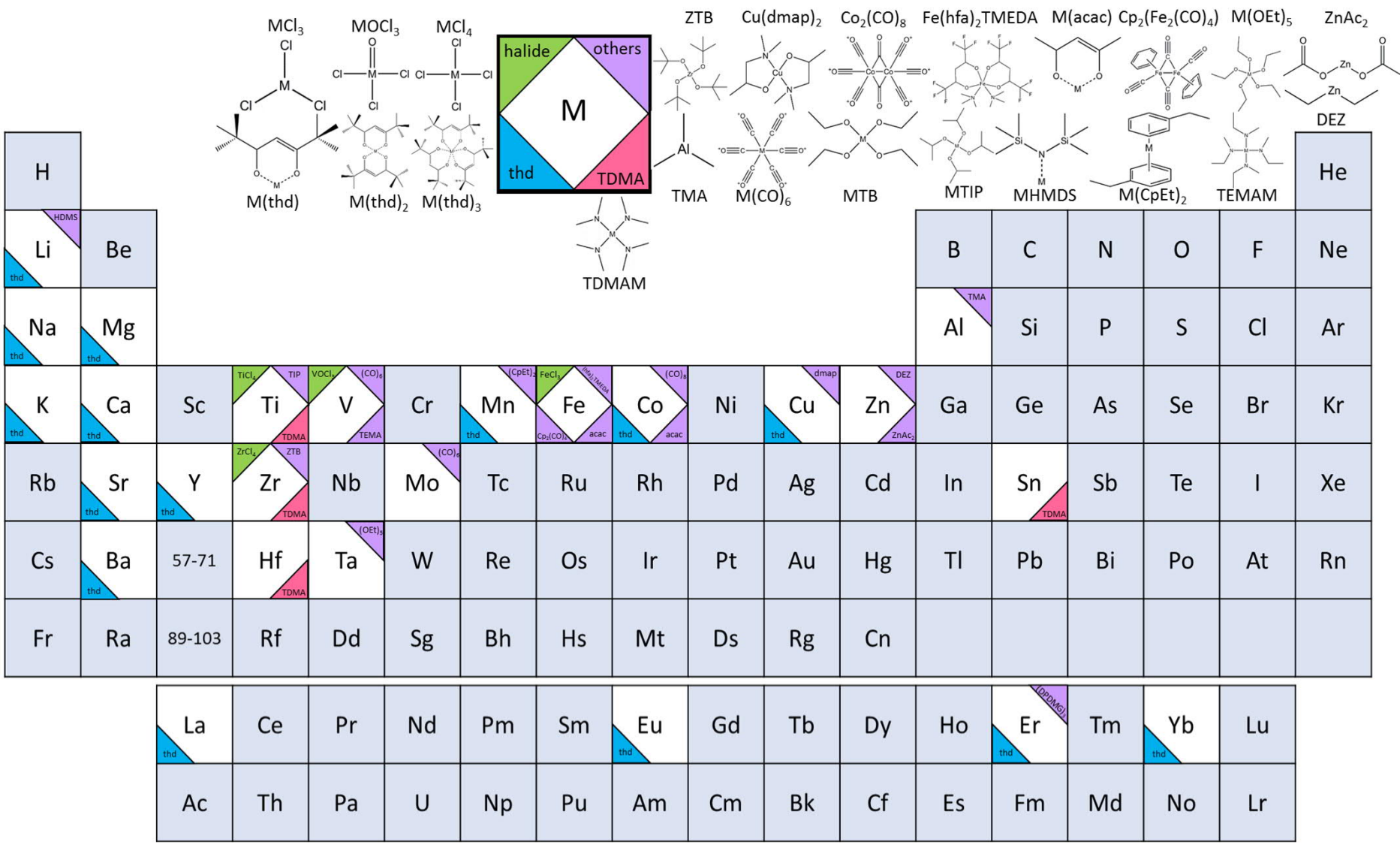
Shao, Umemoto, Kikutani & Okui, *Polymer* **1997**, 38, 459.

Lee, Ryu, Choi, Lee, Im & Sung, *J. Am. Chem. Soc.* **2007**, 129, 16034.

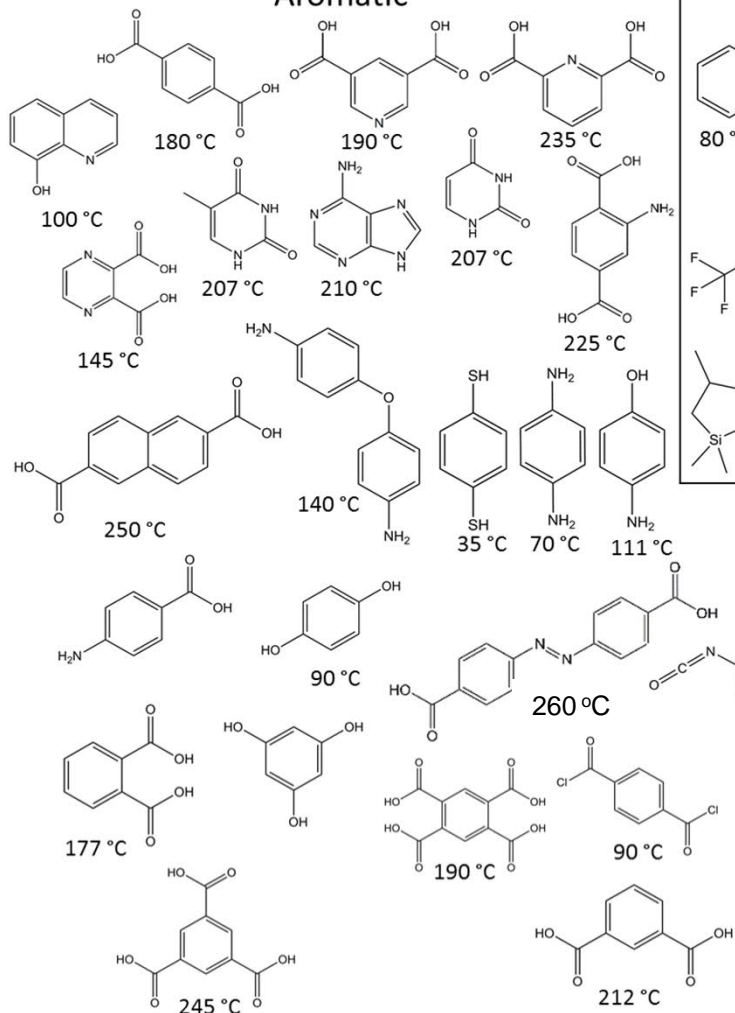
Smirnov, Zemtsova, Belikov, Zheldakov, Morozov, Polyachonok & Aleskovskii, *Dokl. Phys. Chem.* **2007**, 413, 95.

Nilsen, Klepper, Nielsen & Fjellvåg, *ECS Trans.* **2008**, 16, 3.

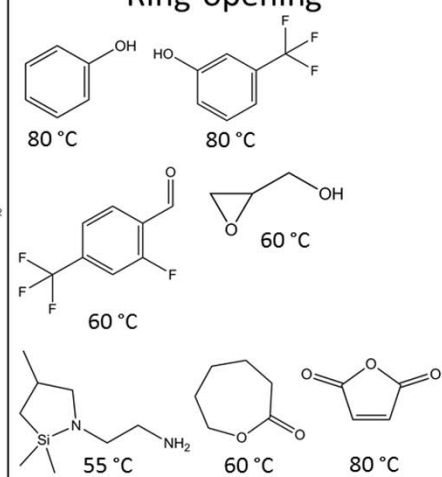
Dameron, Seghete, Burton, Davidson, Cavanagh, Bertrand & George, *Chem. Mater.* **2008**, 20, 3315.



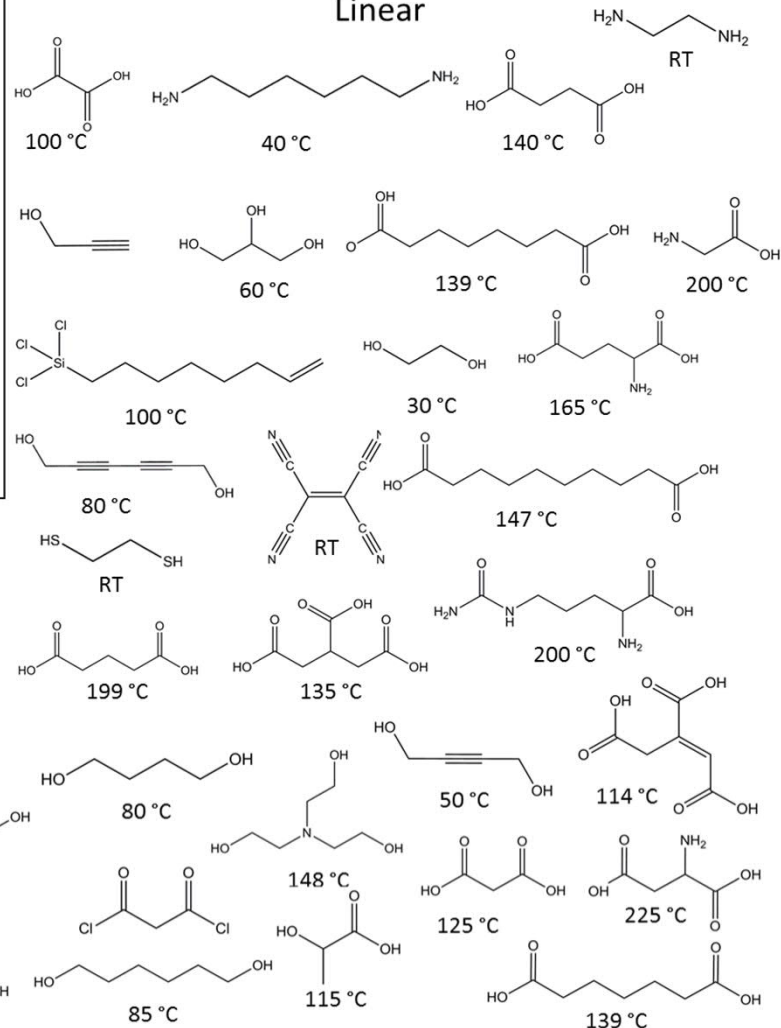
### Aromatic



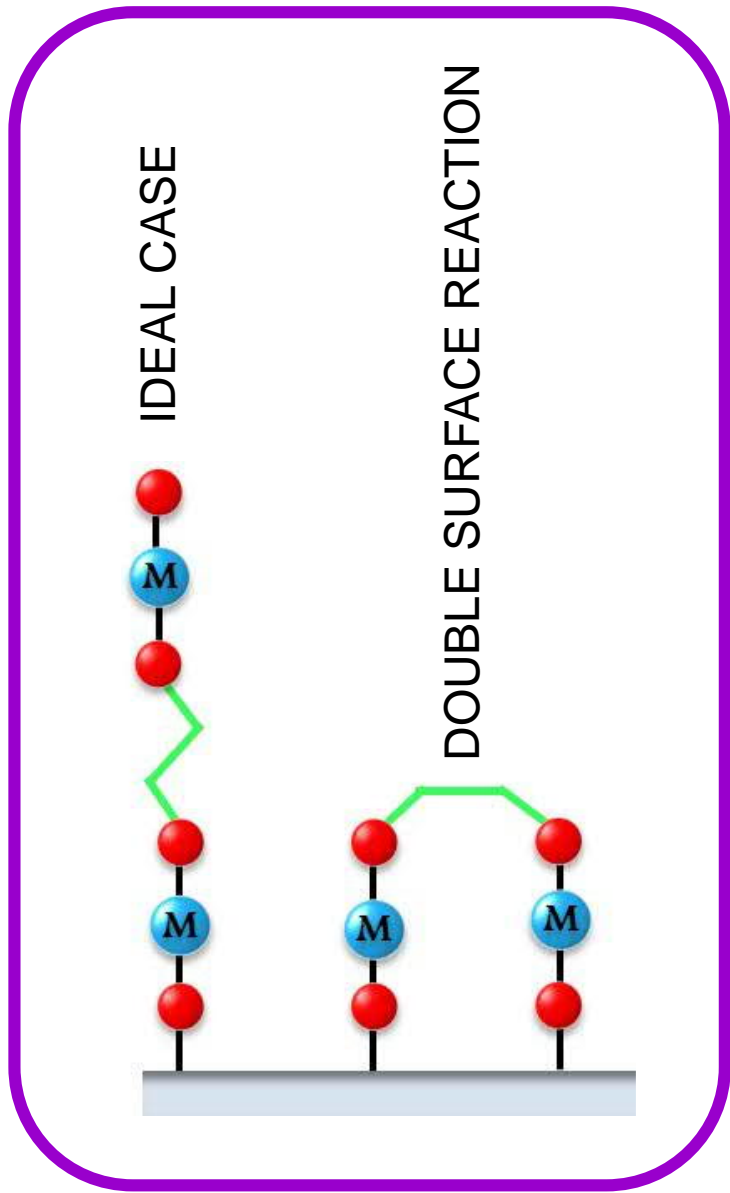
### Ring-opening



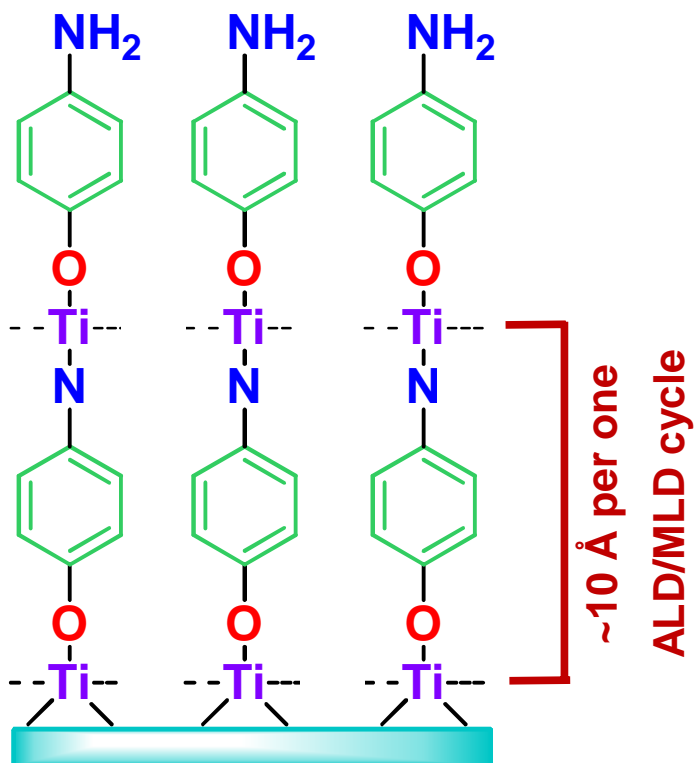
### Linear



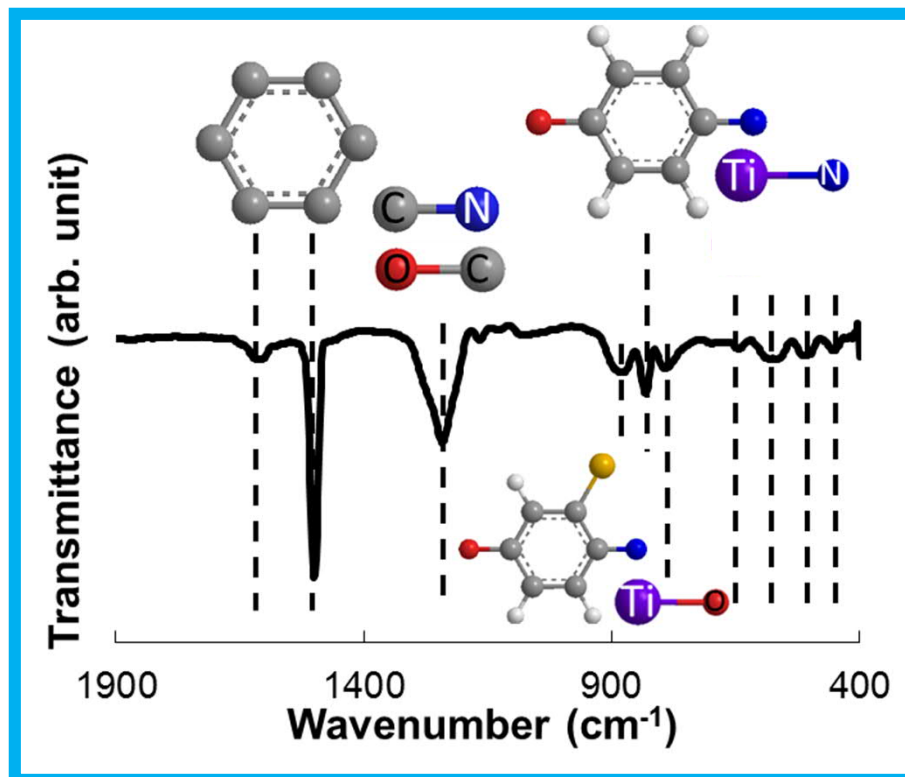




# TiCl<sub>4</sub> + Aminophenol



FTIR



- **Reactivity** of the **functional groups** towards the metal precursor
- Bonding site (e.g. O, N or S) → M-O / M-S / M-S bond in the hybrid
- **Backbone**: size, chemistry, functionality → **Remains in the hybrid !!!**



## EXAMPLES

ALD: H – O – H

HO – CH<sub>2</sub>-CH<sub>2</sub> – OH

HO – benzene – OH

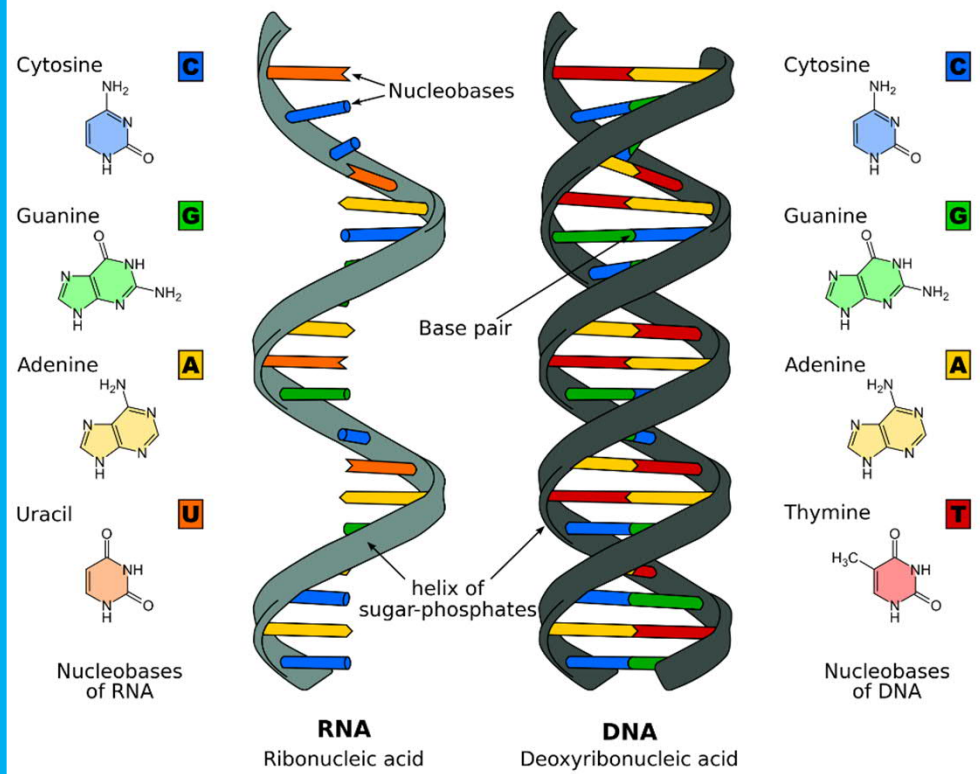
ALD: NH<sub>3</sub>

H<sub>2</sub>N – backbone – NH<sub>2</sub>

ALD: O<sub>3</sub>

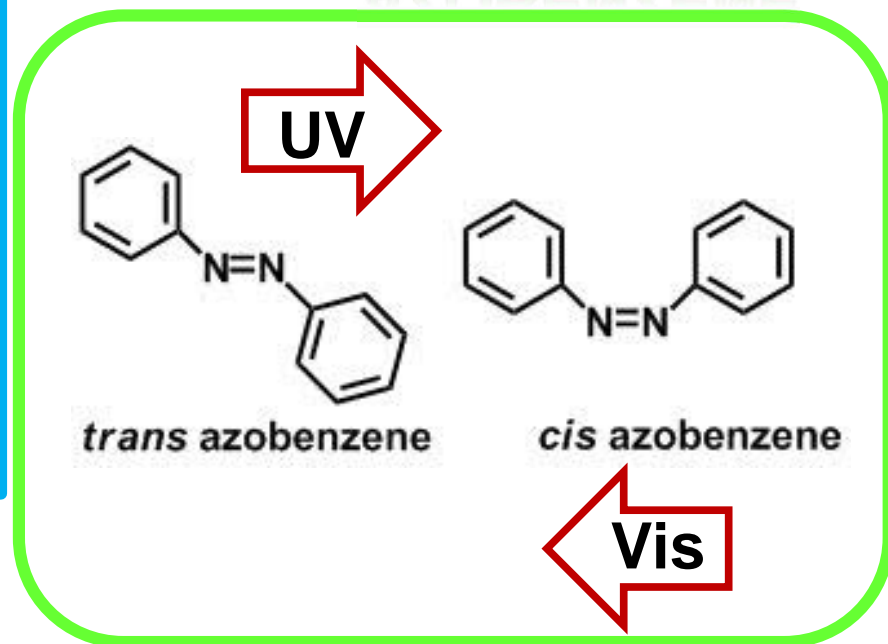
HOOC – backbone – COOH

# NUCLEOBASES FROM NATURE



Z. Giedraityte, O. Lopez-Acevedo, L.A. Espinosa Leal, V. Pale, J. Sainio, T.S. Tripathi & M. Karppinen, *J. Phys. Chem. C* **120**, 26342 (2016).

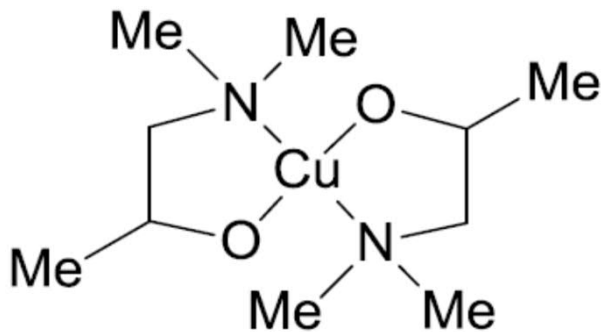
## PHOTORESPONSIVE AZOBENZENE



A. Khayyami & M. Karppinen, *Chem. Mater.* **30**, 5904 (2018).

A. Khayyami, A. Philip & M. Karppinen, *Angew. Chem. Int. Ed.* **58**, 13400 (2019).

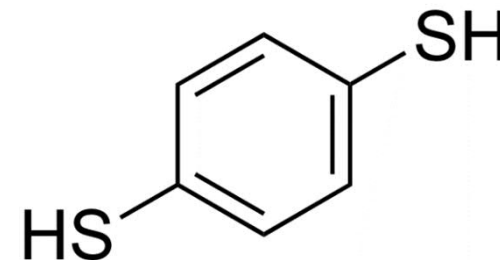




**Cu(dmap)<sub>2</sub>**

**T<sub>subl</sub> = 60 °C**

**7 s / 5 s N<sub>2</sub>**



**Benzene-1,4-dithiol**

**T<sub>subl</sub> = 35 °C**

**10 s / 10 s N<sub>2</sub>**

**Low-temperature ALD/MLD**

**T<sub>dep</sub> = 80 – 140 °C**

**GPC = 1.9 – 0.8 Å/cycle**



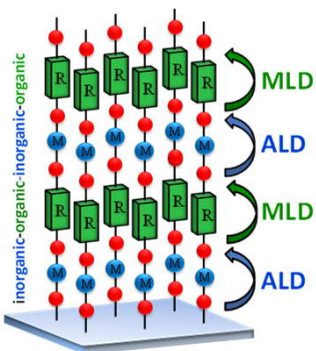
Organic (e.g. benzene)



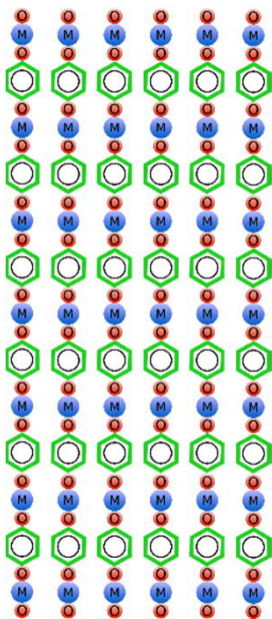
Metal



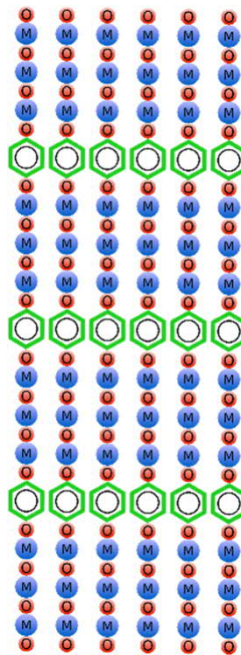
Oxygen (or N, S, ...)



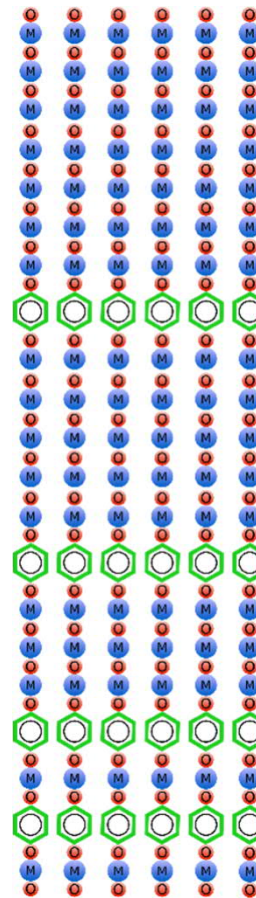
Simple  
Metal-Organic Network  
(amorphous or **crystalline**)



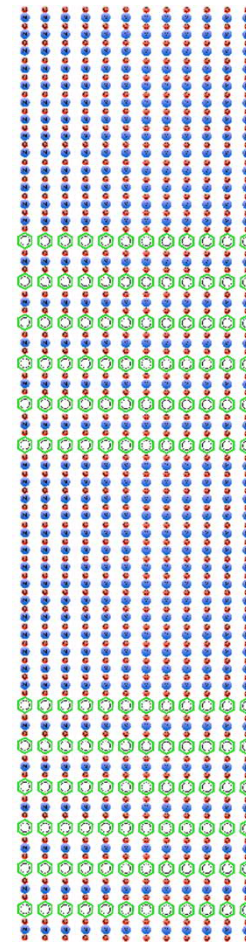
**Superlattice**



**Gradient hybrid**



**Nanolaminate**

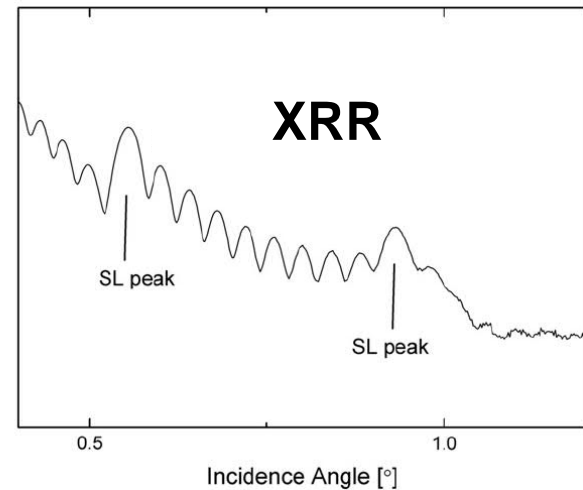
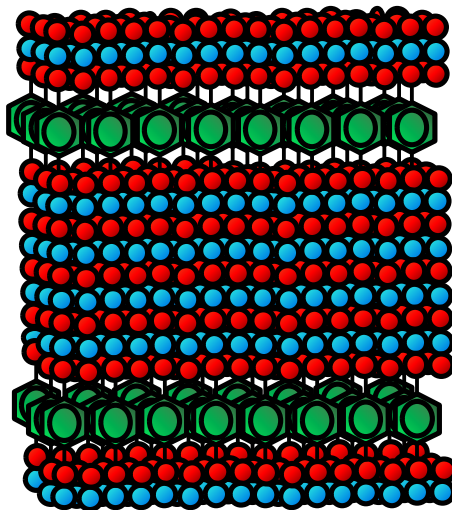


**A!**

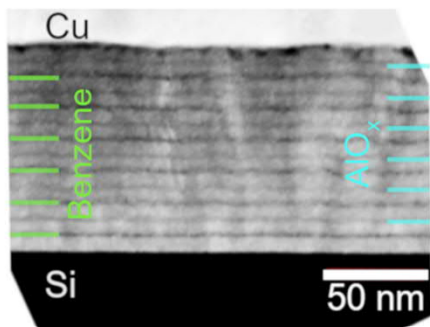
Aalto University  
School of Chemical  
Engineering

**DIFFERENT LAYER SEQUENCES BY DESIGN**

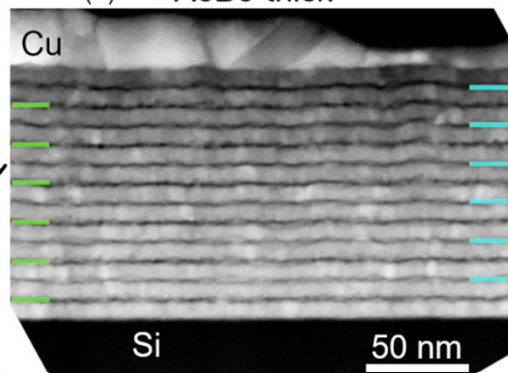
# ZnO:benzene SUPERLATTICE



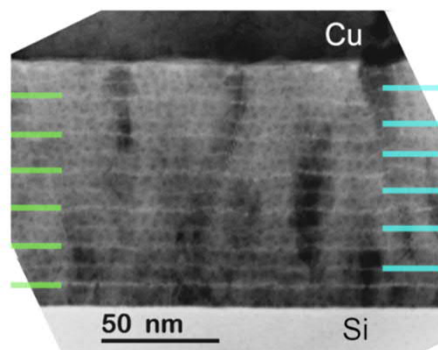
(a) A6B6



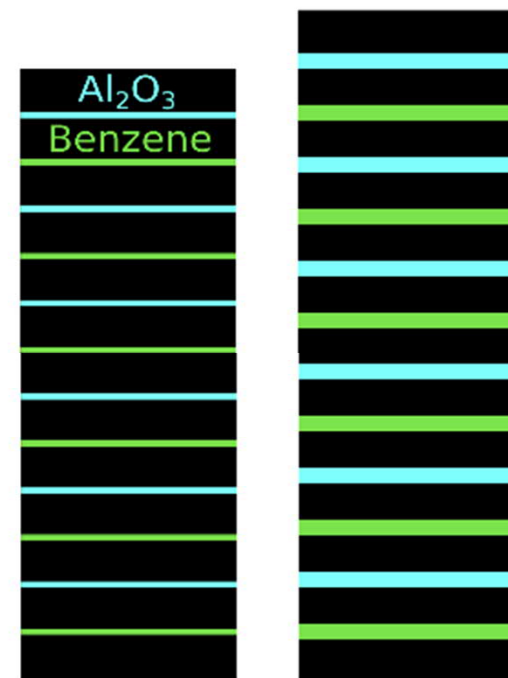
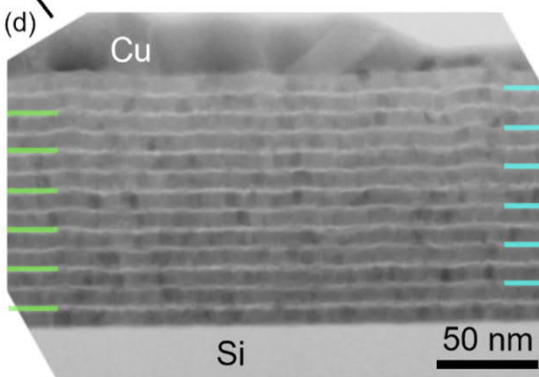
(b) A6B6-thick



(c)



(d)



A6B6 A6B6-thick

# POSSIBLE APPLICATIONS OF ALD/MLD FILMS ...

## ■ **GAS-BARRIER COATINGS**

$\text{Al}_2\text{O}_3$  + hybrid Al-organic nanolaminate coatings on biopolymers:

→ **Enhanced mechanical & thereby oxygen-gas barrier properties**

## ■ **UV- and IR-to-Vis Conversion Layers for SOLAR CELLS**

Ln-organic (Ln = e.g. Eu, Yb, Er) films with UV or IR-absorbing organics

→ **More efficient utilization of solar radiation**

## ■ **FLEXIBLE Li-ORGANIC MICROBATTERY**

Not-previously-existing Li-organic electrode materials

→ **First all-organic Li-ion microbattery**

## ■ **TEXTILE-INTEGRATED THERMOELECTRICS**

ZnO-organic superlattice structures in a scale of 1~10 nm

→ **Suppressed thermal conductivity/enhanced TE characteristics**

## ■ **FLEXIBLE CRM-FREE MAGNETIC THIN FILMS**

epsilon- $\text{Fe}_2\text{O}_3$ -organic superlattice thin films → **enhanced mechanical properties without compromising the magnetic properties**



# BIODEGRADABLE & SUSTAINABLE PACKAGING MATERIALS: Polylactic acid (PLA)

- biodegradable & sustainable
- PROBLEM:** oxygen transmission rate too large:

$$\text{OTR} = 400 \text{ cm}^3/\text{m}^2 \text{ d}10^5 \text{ Pa}$$

## SOLUTION:

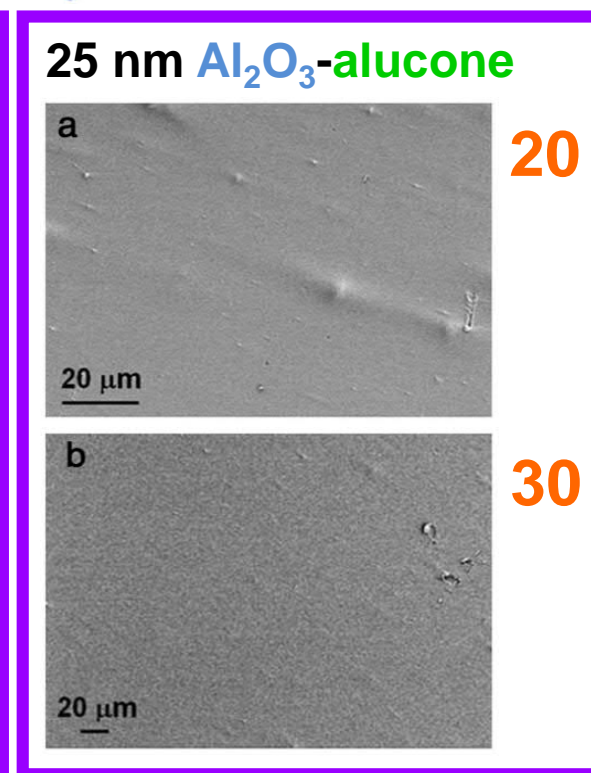
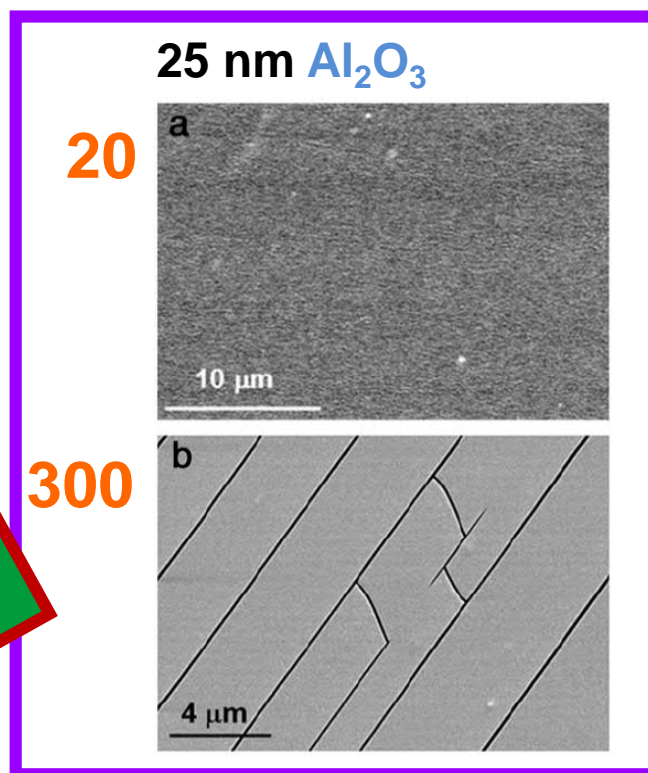
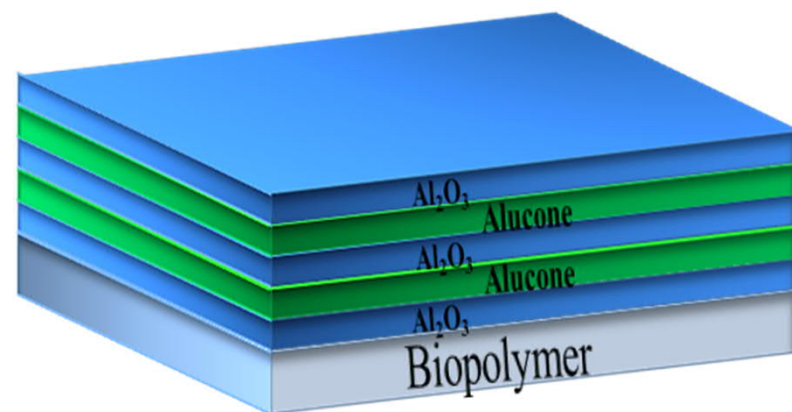
thin (25 nm) ALD- $\text{Al}_2\text{O}_3$  coating:

$$\text{OTR} = 20 \text{ cm}^3/\text{m}^2 \text{ d}10^5 \text{ Pa}$$

- PROBLEM:** strain induces cracks & deteriorates barrier properties of ALD- $\text{Al}_2\text{O}_3$

## SOLUTION:

$\text{Al}_2\text{O}_3$  + alucone  
(-Al-O-CH<sub>3</sub>-CH<sub>3</sub>-O-)  
nanolaminate coating  
by ALD/MLD

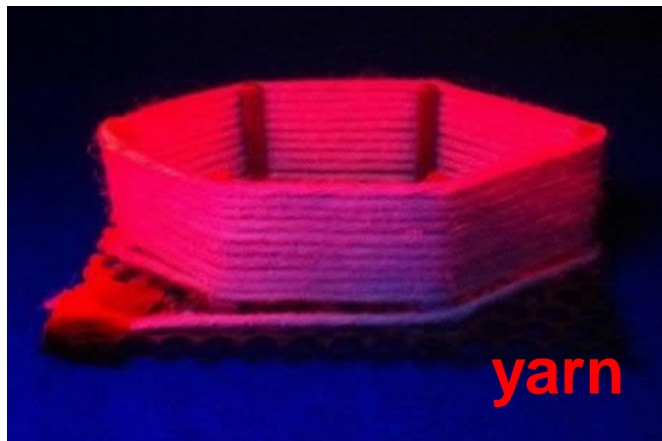
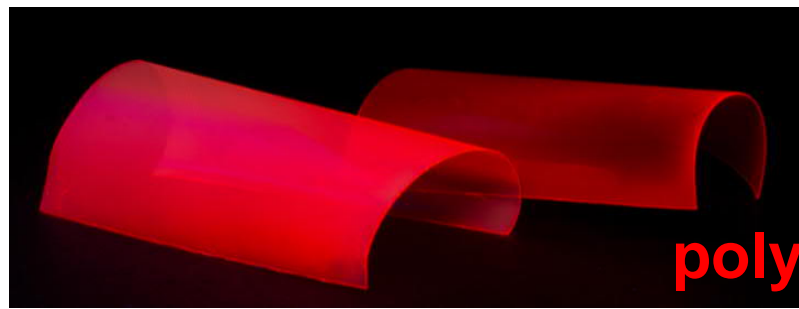
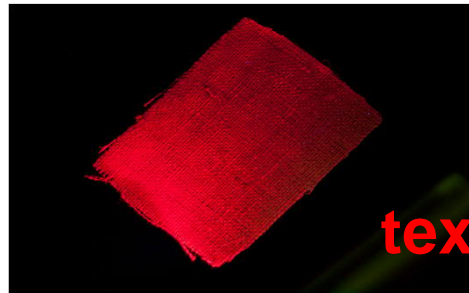


3% strain

# PHOTOLUMINESCENCE: Flexible Eu-hybrid thin films

PRECURSORS:

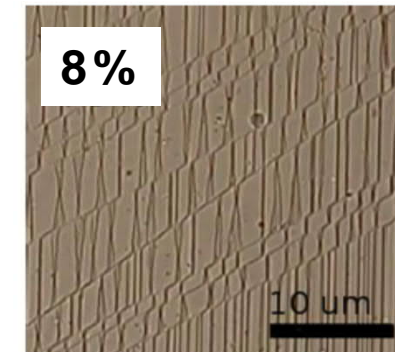
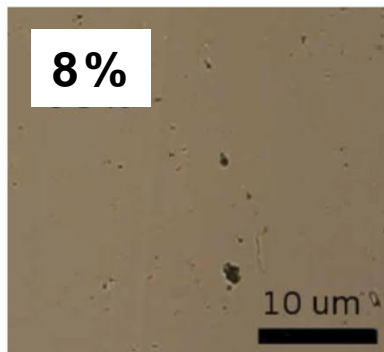
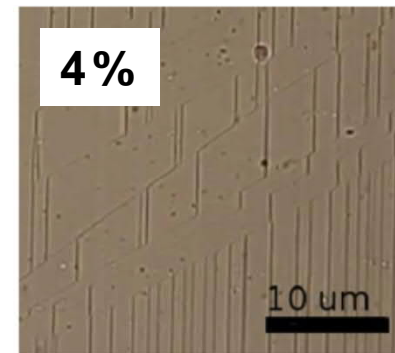
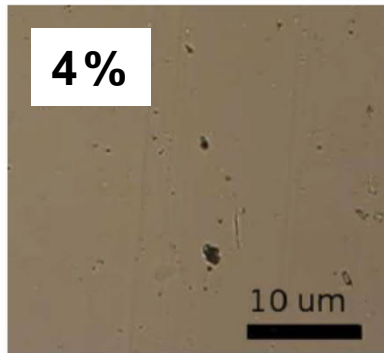
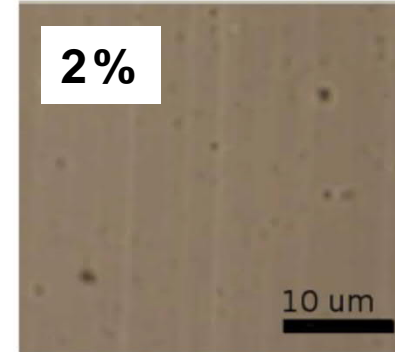
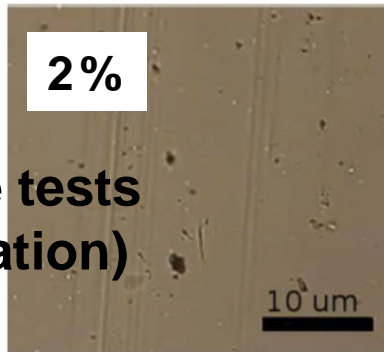
Eu(thd)<sub>3</sub> + pyridinedicarboxylic acid



**Eu-hybrid**

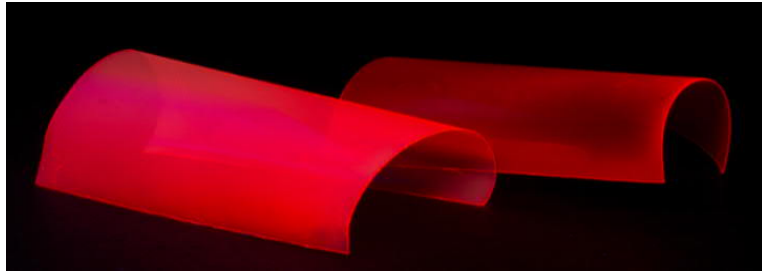
**Eu<sub>2</sub>O<sub>3</sub>**

Tensile tests  
(elongation)

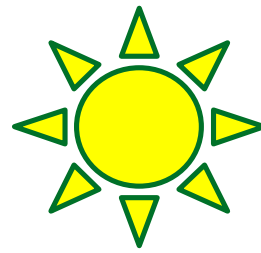


Z. Giedraityte, P. Sundberg & M. Karppinen,  
*J. Mater. Chem. C* 3, 12316 (2015).

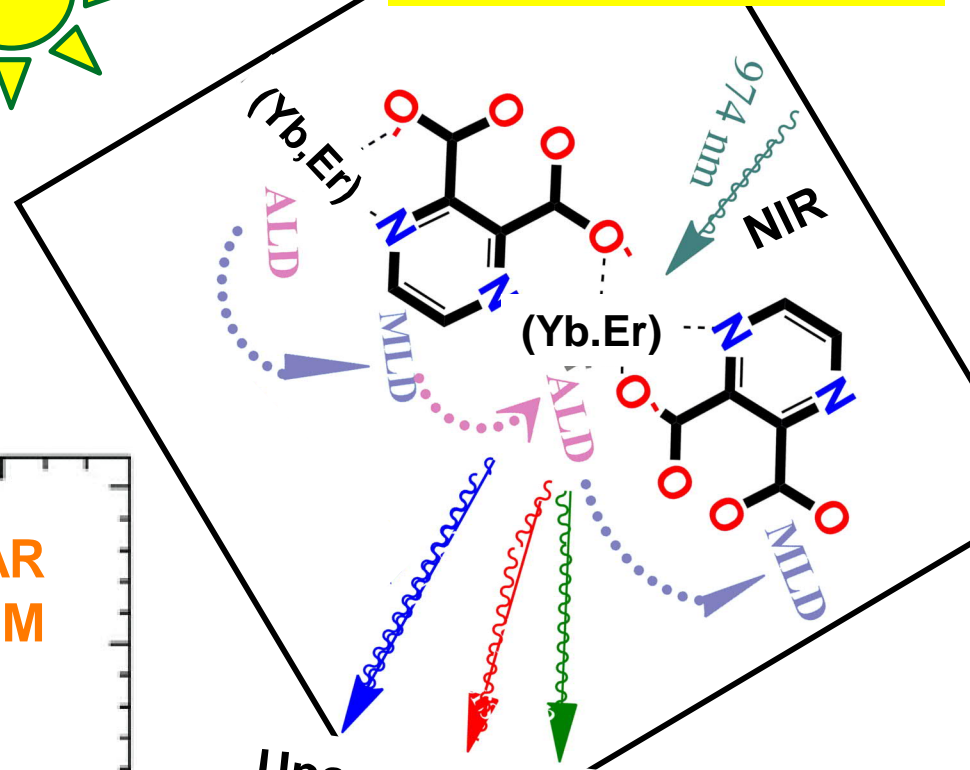
**PHOTOLUMINESCENCE:**  
VIS from UV radiation



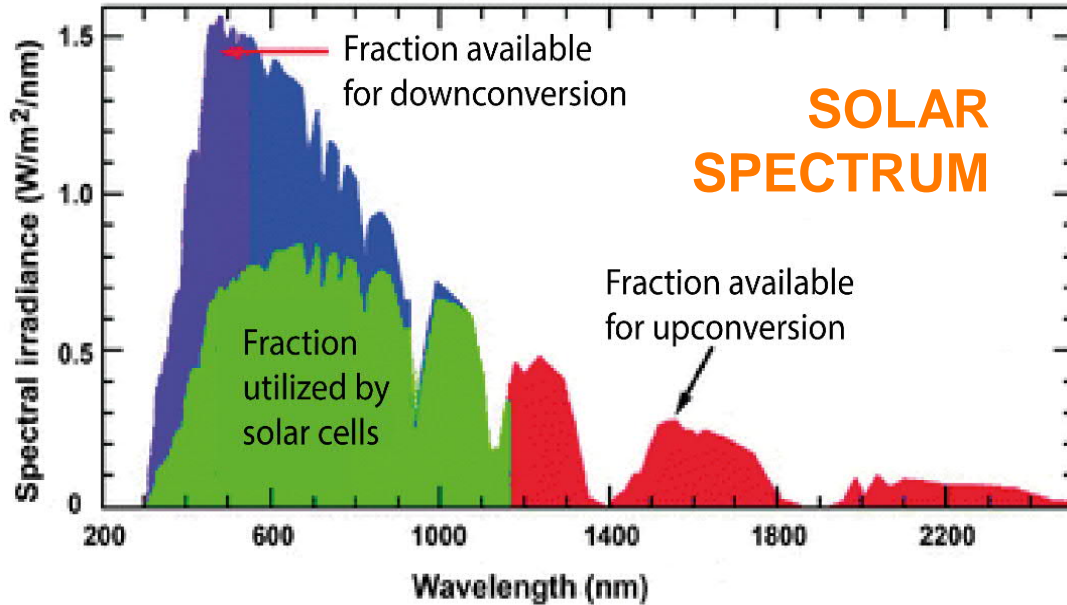
**Eu-organic ALD/MLD films**



**UPCONVERSION:**  
VIS from NIR radiation



← UV VIS NIR →



**Upconversion  
in VIS**

**(Yb,Er)-organic ALD/MLD films**



## ■ Metal Coordination Complex

- central metal atom + ligands

## ■ Coordination Network

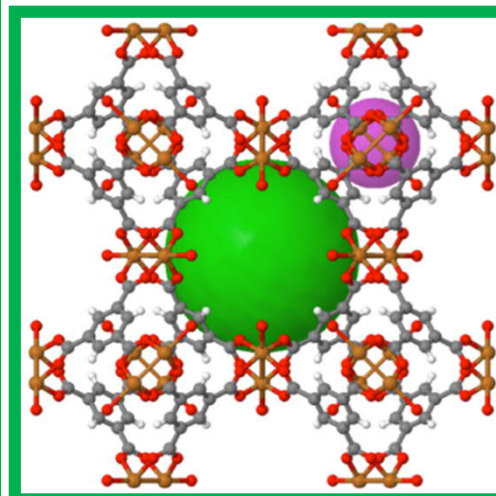
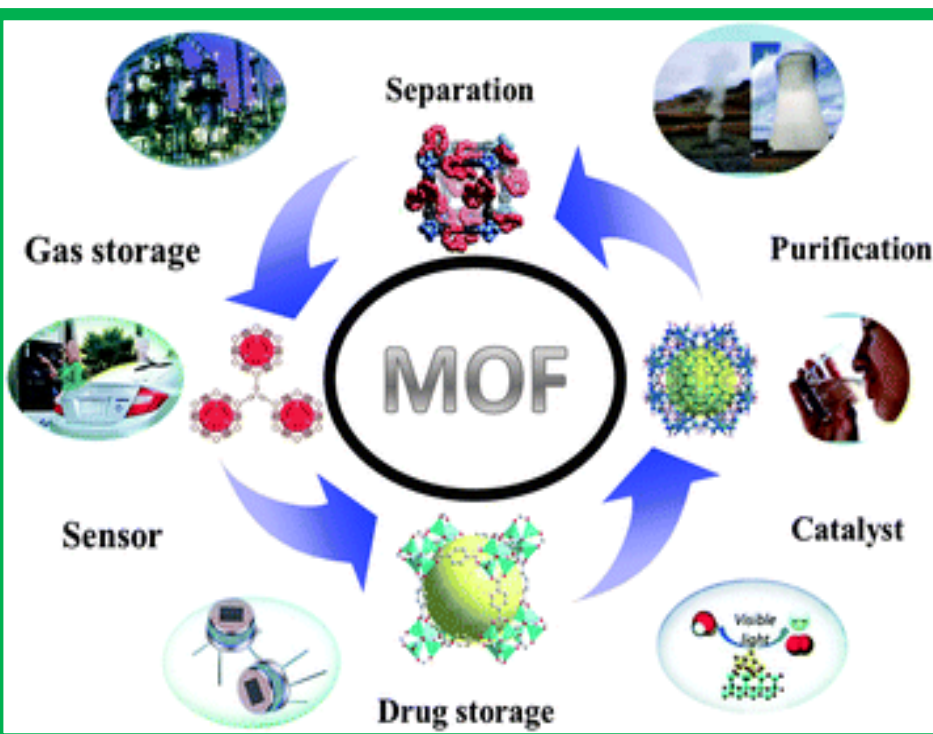
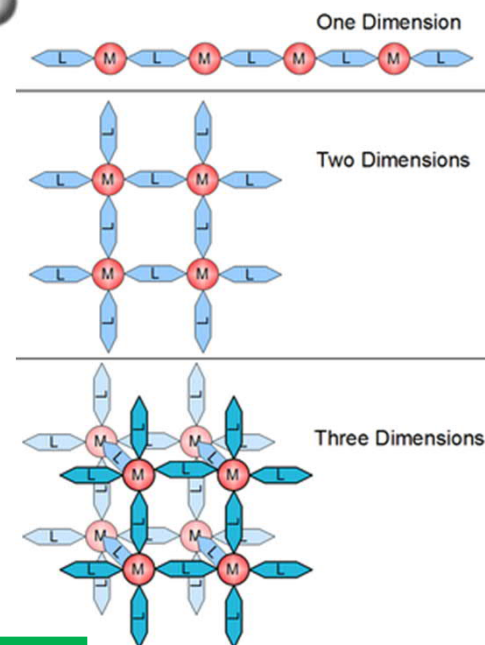
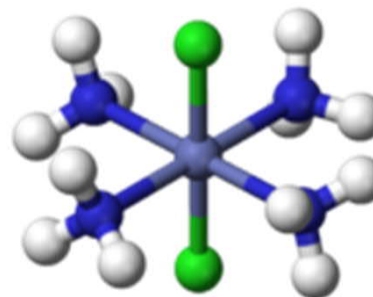
- organic ligands act as linkers

- 1D, 2D or 3D materials

## ■ Metal Organic Framework (MOF)

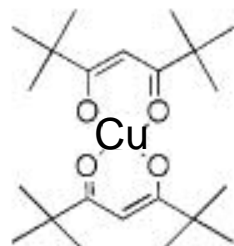
- highly porous materials

- attractive application possibilities

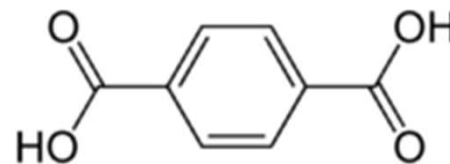




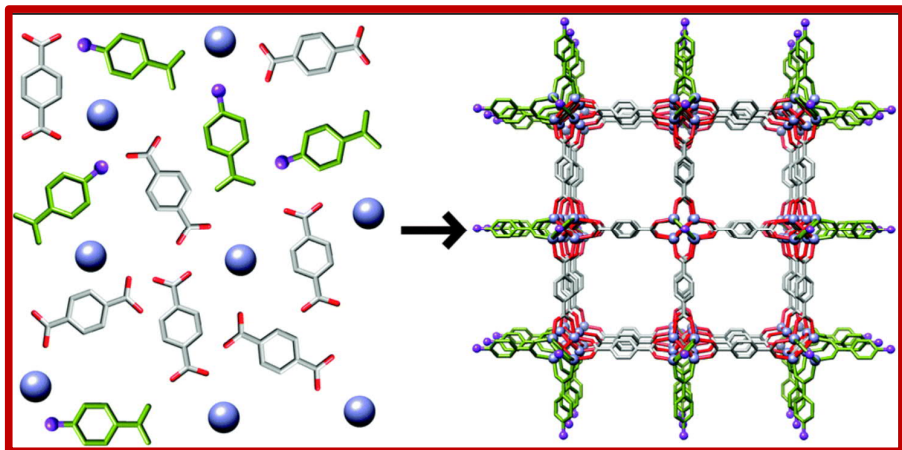
# PRECURSORS for ALD/MLD



Cu(thd)<sub>2</sub>



Terephthalic acid (TPA)



# MOF

METAL-ORGANIC  
FRAMEWORK

E. Ahvenniemi & M. Karppinen,  
Chem. Commun. **52**, 1139 (2016).

Density 2.1 g/cm<sup>3</sup>

Dep. Temp.

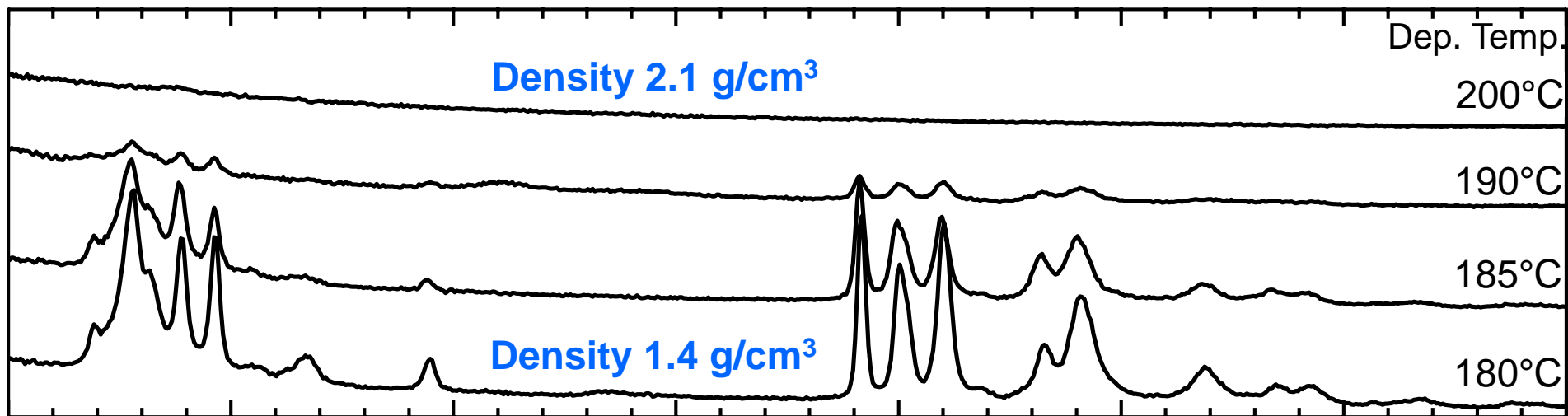
200°C

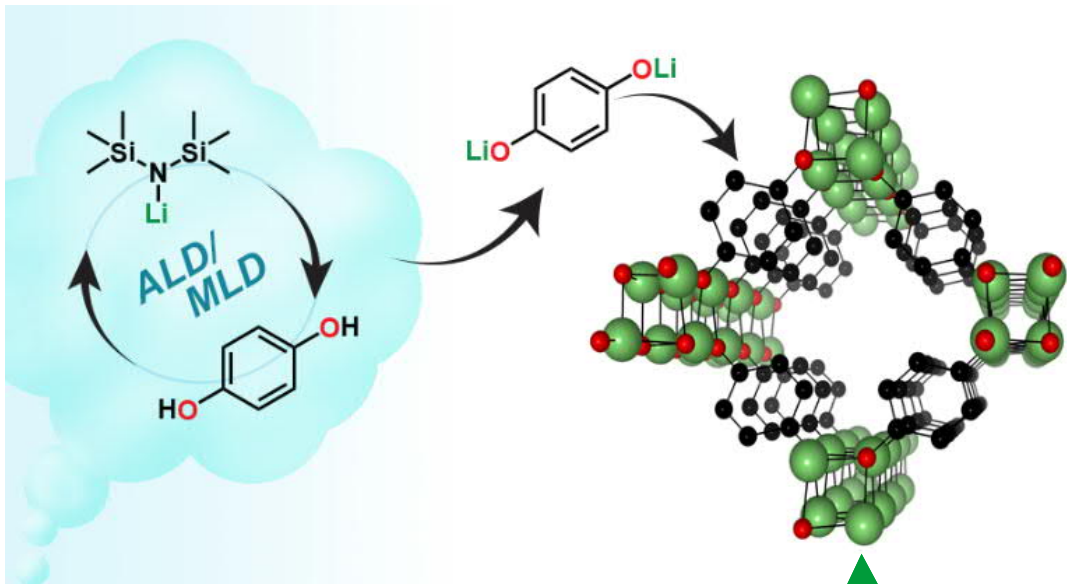
190°C

185°C

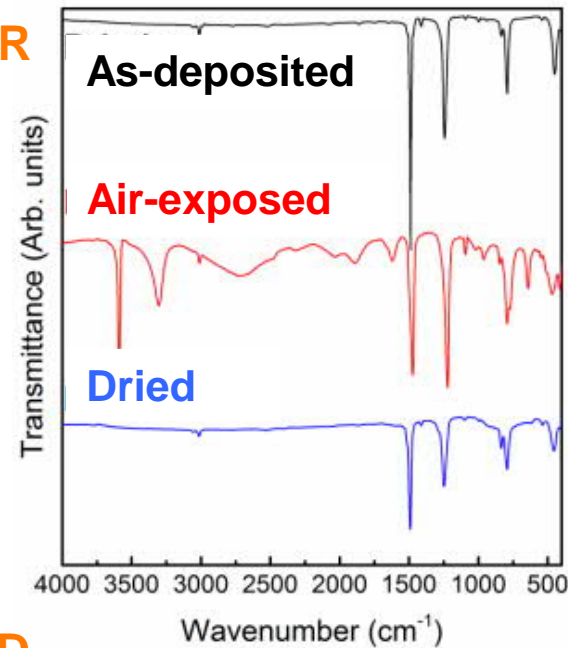
Density 1.4 g/cm<sup>3</sup>

180°C

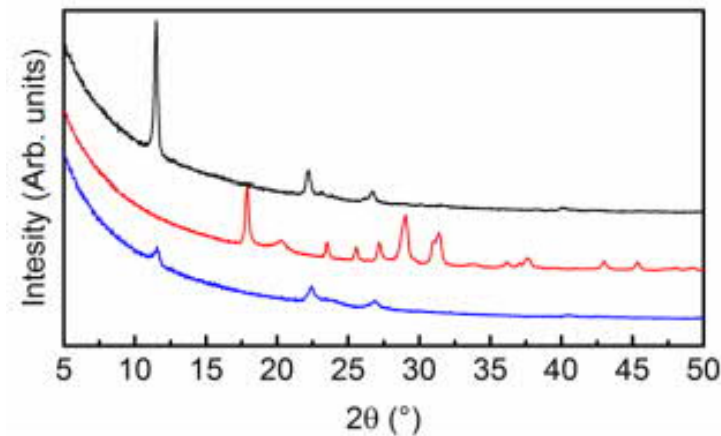




FTIR



XRD



Structure predicted by DFT

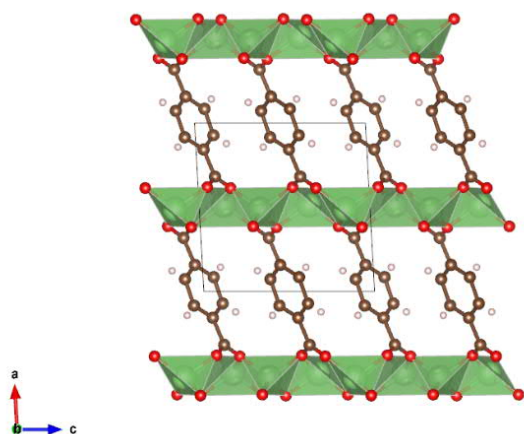
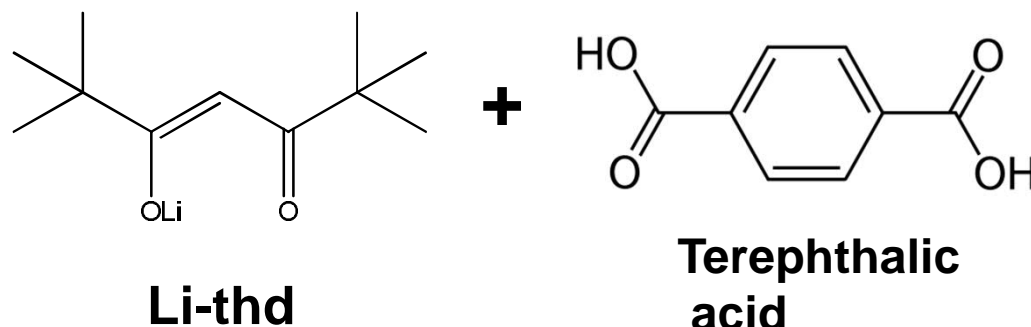
## Li + Hydroquinone

- Crystalline films
- NOT synthesized by any other technique
- Under-coordinated Li-site
- Reversible water absorption (gas absorption)
- Potential application: Li-ion battery cathode

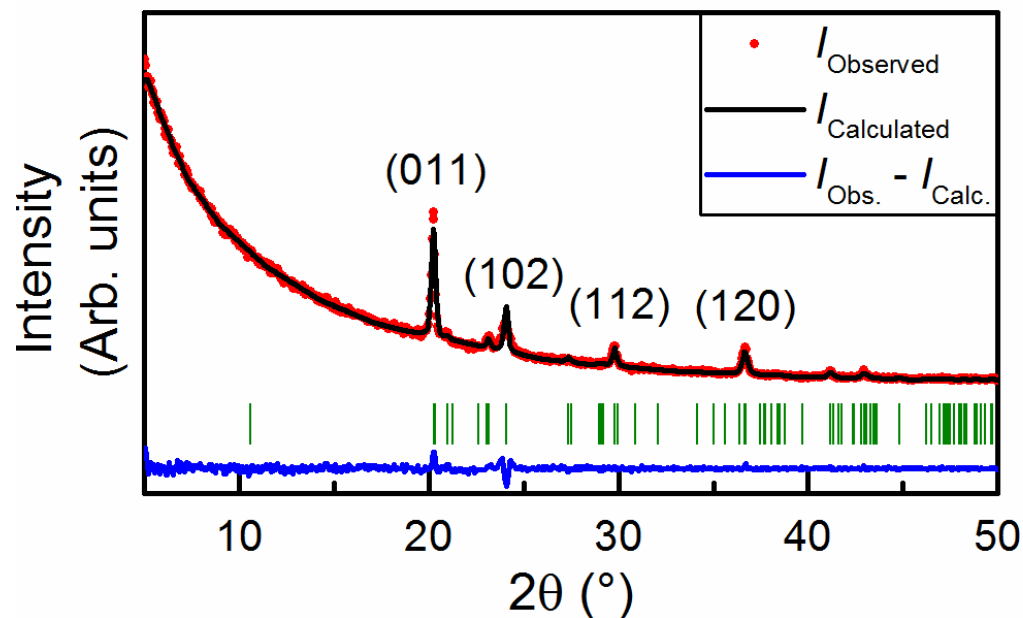
# ANODE

## Li-terephthalate

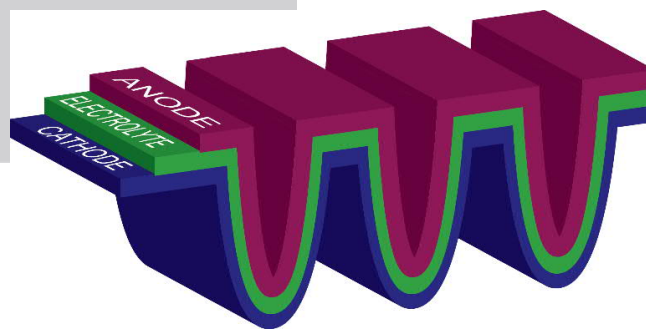
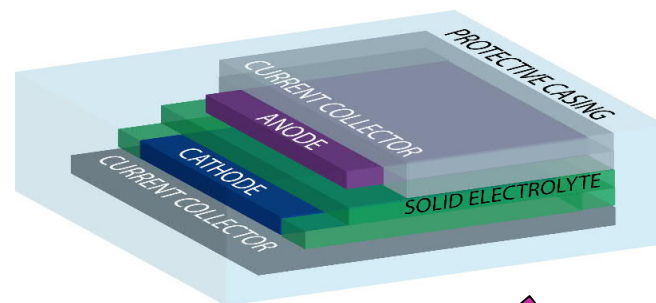
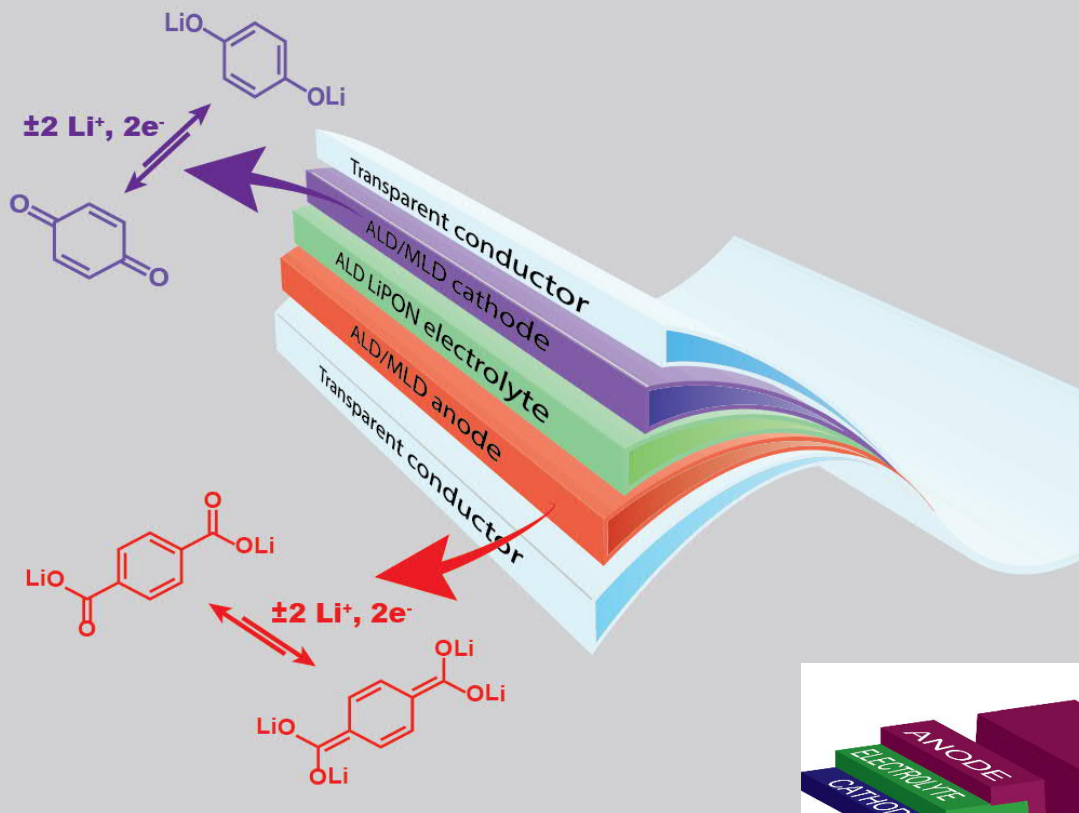
ALD/MLD:  
Li-thd + TPA



Layered structure with  
alternating layers of  
 $\text{LiO}_4$  tetrahedra & benzene-rings



# Flexible Li-organic microbattery



3D

HIGH POWER & ENERGY DENSITY



# Inorganic-Organic INTERFACES:

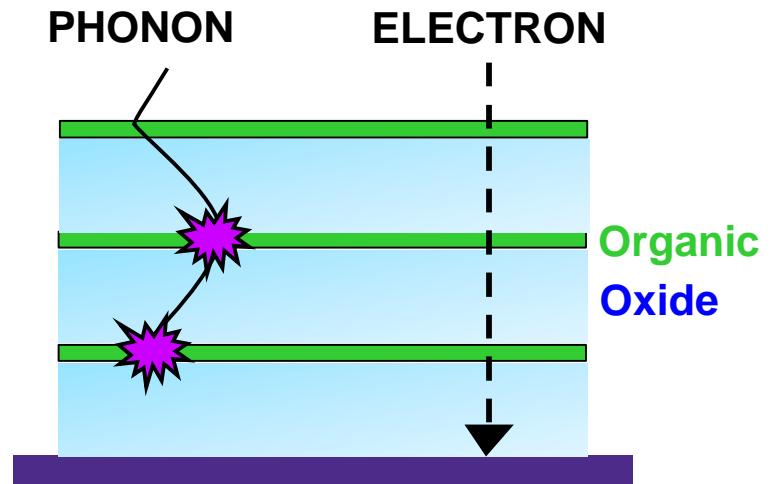
## Reduction of Thermal Conductivity

- Thermal conductivity ( $\kappa$ ) is important: thermal barriers, thermoelectrics, etc.
- Interfaces in the form of superlattice: **metal oxide layers** & **organic layers**
- Proof-of-concept data: **ZnO:benzene** in a scale of 1 ~ 20 nm for ZnO

Thermoelectric  
figure-of-merit

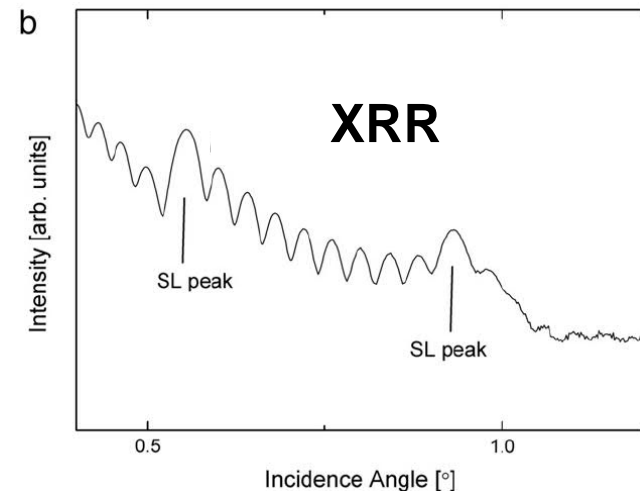
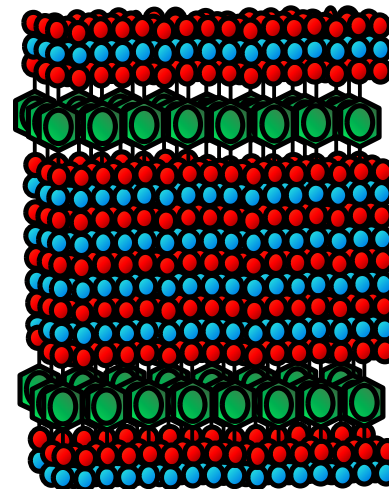
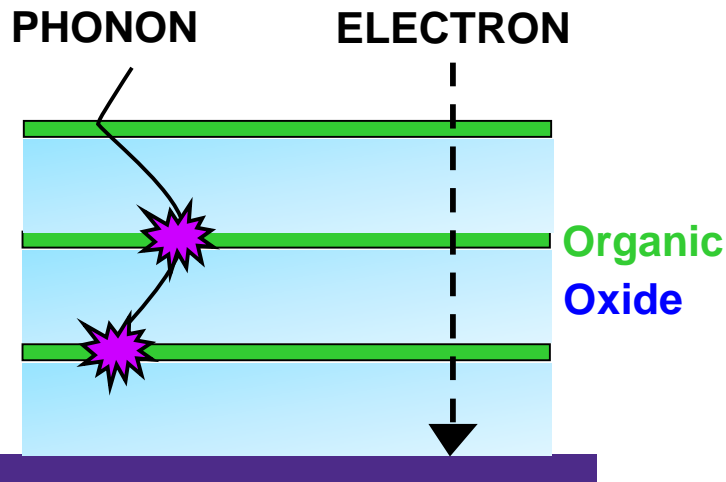
$$ZT = \frac{S^2 \sigma}{\kappa_e + \kappa_l} T$$

For oxides:  $\kappa_l$  large !

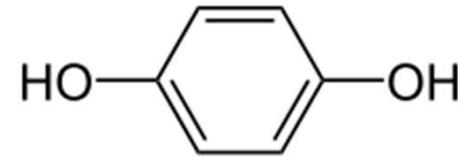
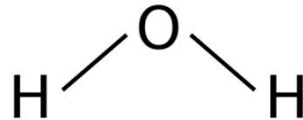
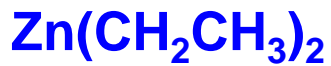


# THERMOELECTRIC MATERIALS

- High electrical conductivity & Low thermal conductivity  
→ Difficult combination to be achieved with conventional materials
- ALD/MLD thin-film technology → nanoscale **SUPERLATTICE (SL)**:
  - thermoelectric oxide layers (ZnO) by ALD & organic (benzene) layers by MLD
  - thermal conductivity decreases but electrical conductivity remains the same
- XRR: we can see SL peaks as an indication of the regular ordered SL structure



# ALD/MLD for ZnO : Benzene superlattice



## DEPOSITIONS

- 220 °C
- 600 ALD/MLD cycles in total

ZnO, 0-99 layers

Single organic layer

ZnO, 1-100 layers

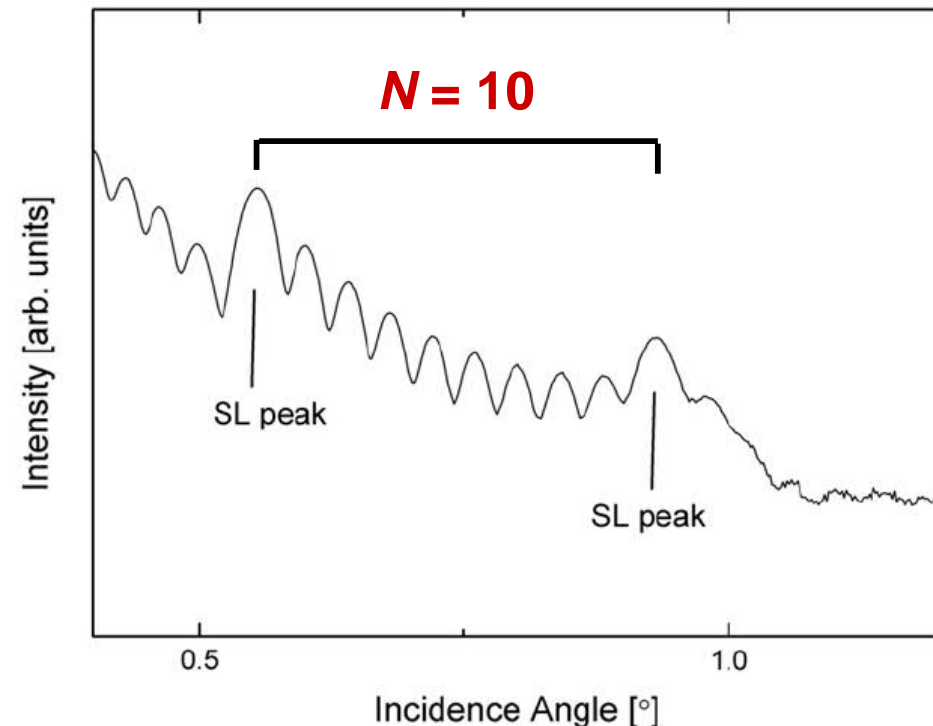
Substrate

Repeat  
 $N$  times



~100 nm

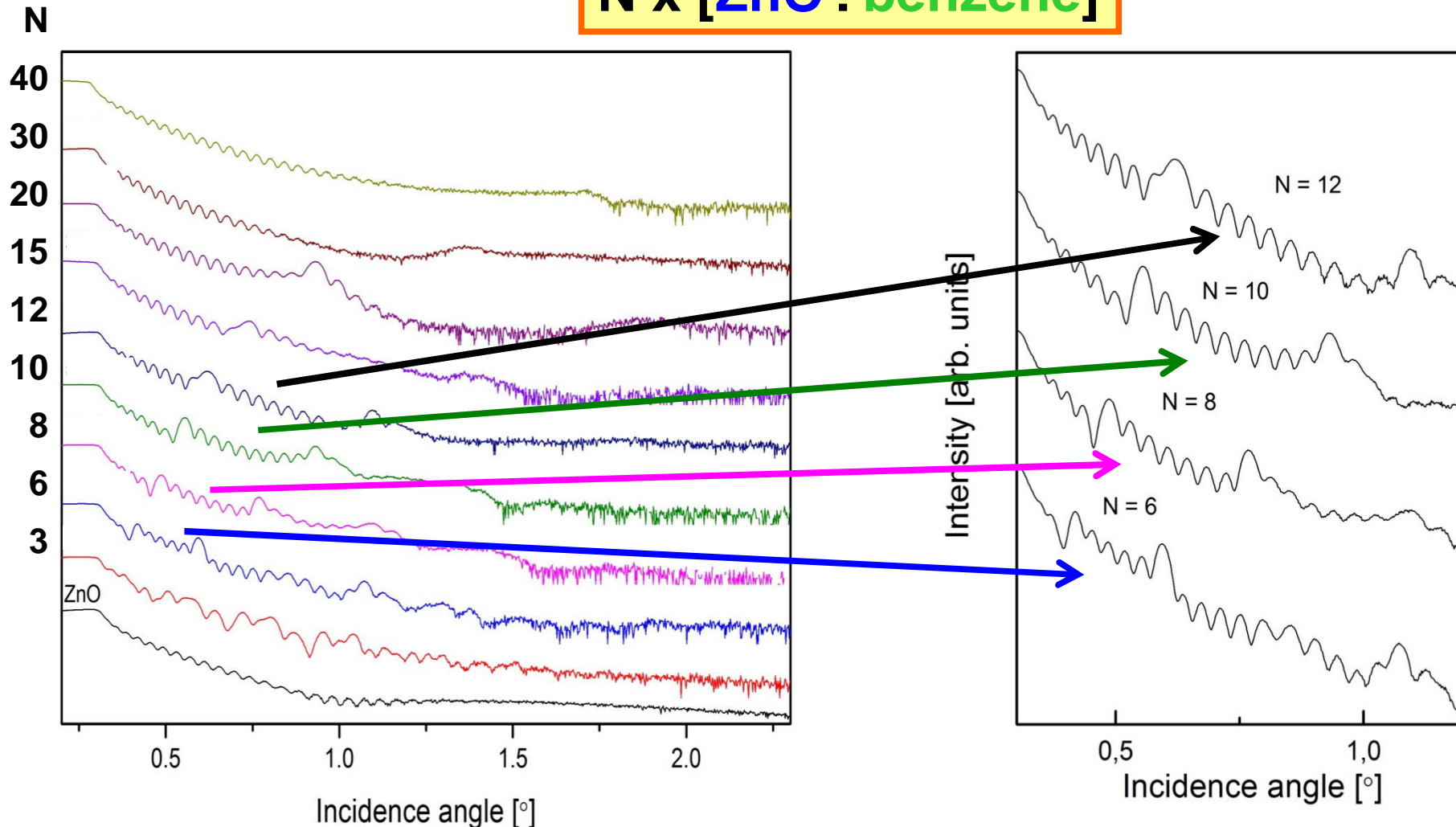
## XRR: X-ray Reflectivity



## XRR:

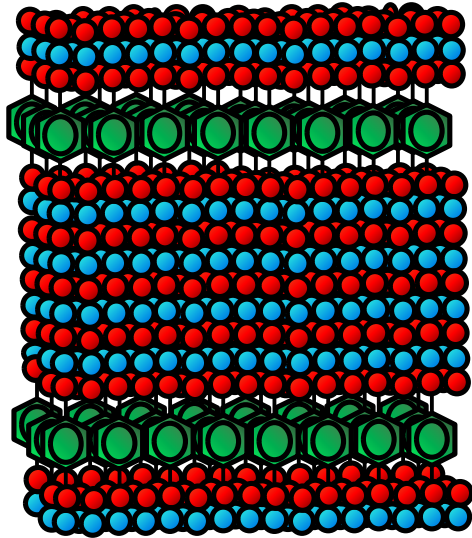
- We can see/count the number (N) of "superlayer" units in the SL thin film; most clearly for N = 6 to 12; for N > 12 the oscillations start to overlap
- NOTE: for ZnO no SL peaks are seen

N x [ZnO : benzene]





# ZnO : benzene



## SUPERLATTICE PERIOD

99 : 1 → 16 nm  
49 : 1 → 8 nm  
29 : 1 → 5 nm  
9 : 1 → 2 nm  
4 : 1 → 1 nm

## THERMAL CONDUCTIVITY (at RT)

Sample	K [W m <sup>-1</sup> K <sup>-1</sup> ]
ZnO	~43
ZnO : benzene (99 : 1)	7.1
ZnO : benzene (49 : 1)	4.1
ZnO : benzene (29 : 1)	3.1
ZnO : benzene (9 : 1)	1.3
ZnO : benzene (4 : 1)	0.7

- T. Tynell, A. Giri, J. Gaskins, P.E. Hopkins, P. Mele, K. Miyazaki & M. Karppinen, *J. Mater. Chem. A* **2**, 12150 (2014).
- A. Giri, J.-P. Niemelä, C.J. Szwejkowski, M. Karppinen & P.E. Hopkins, *Phys. Rev. B* **93**, 024201 (2016).
- A. Giri, J.-P. Niemelä, T. Tynell, J. Gaskins, B.F. Donovan, M. Karppinen & P.E. Hopkins, *Phys. Rev. B* **93**, 115310 (2016).

Using the ALD/MLD technique it is possible to perfectly control where within the ZnO film the organic (benzene) layers are placed → We can grow both regular superlattice films and irregular “gradient” ZnO-organic films. For example, in both of the following two films

Total film thickness: ~105 nm

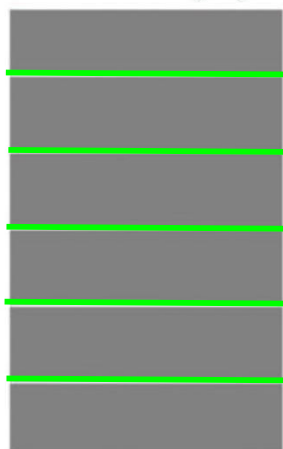
Number of organic layers: 5

Average ZnO layer thickness: ~17 nm

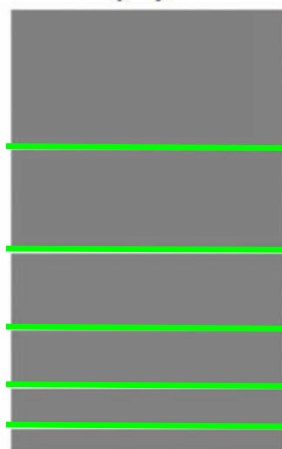
**Superlattice:** all ZnO layers ~17 nm (thermal conductivity

**Gradient film:** ZnO layers 9 ~ 28 nm

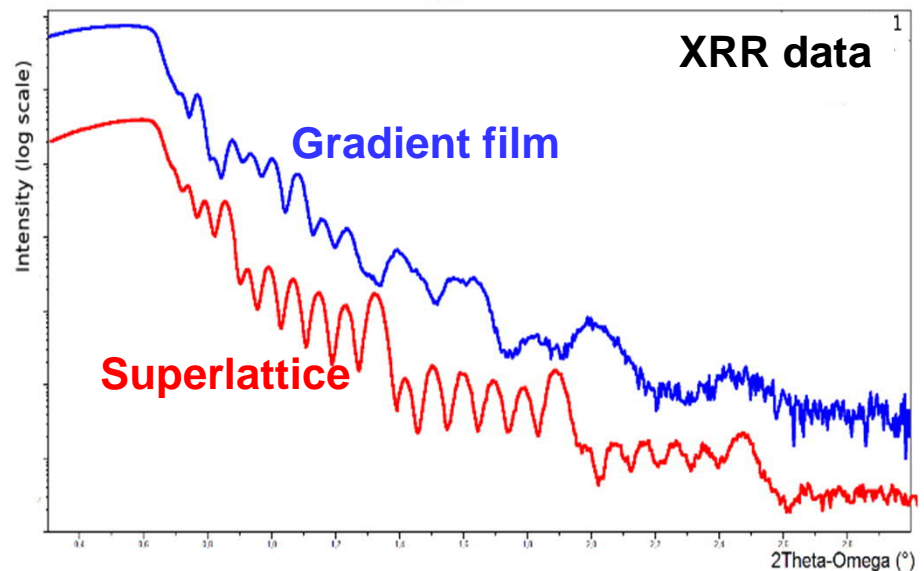
**ONLY** for the former the SL peaks are seen in XRR data



**Superlattice**



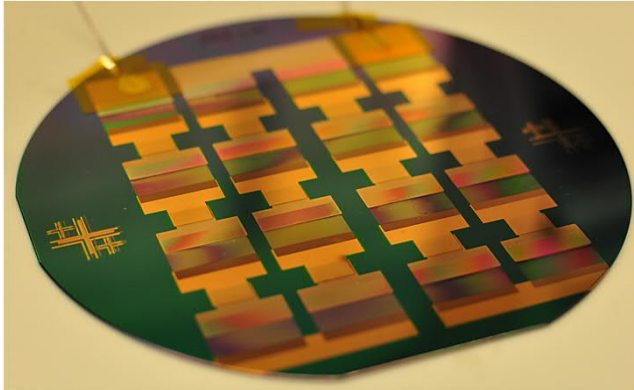
**Gradient film**



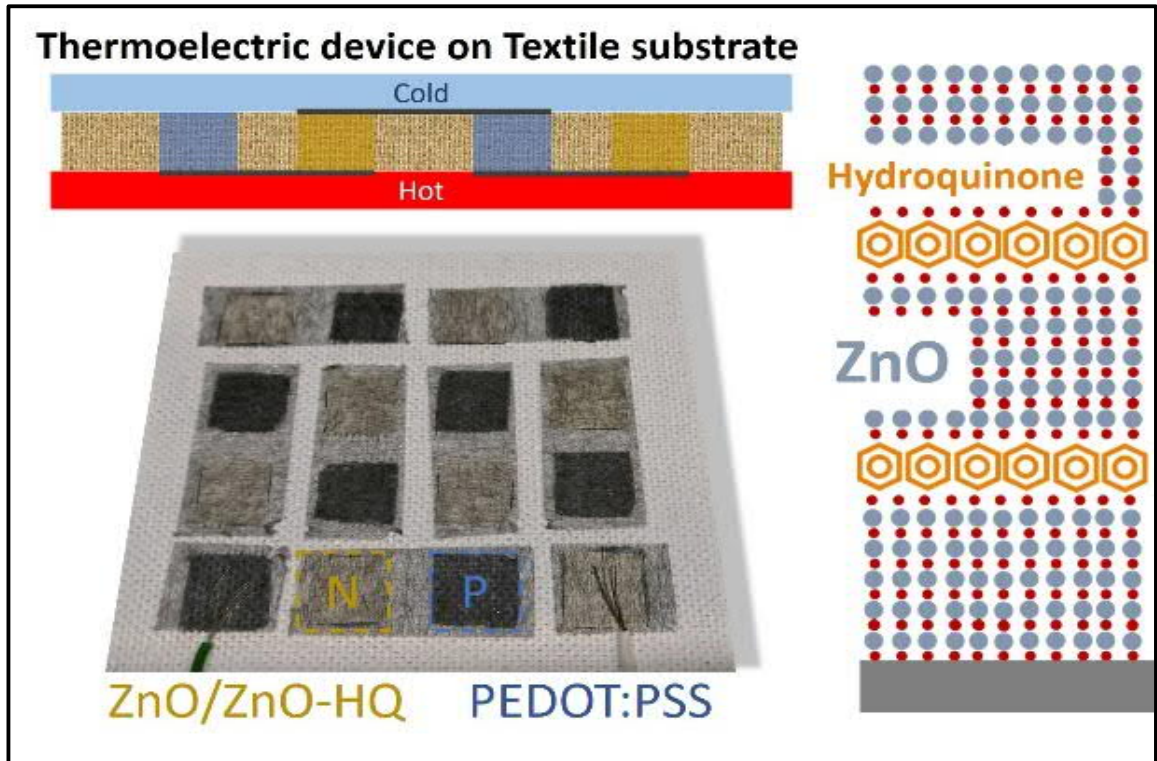
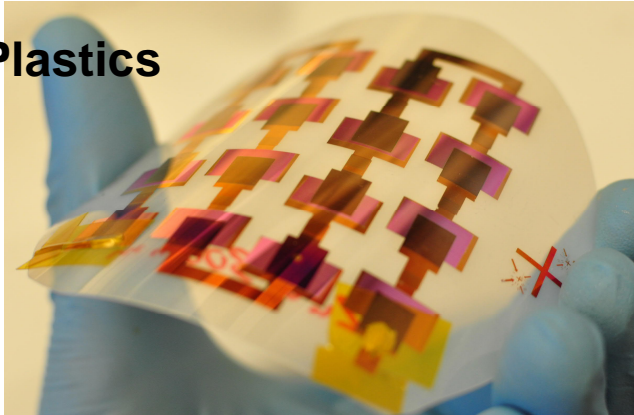
F. Krahl, A. Giri, J.A. Tomko, T. Tynell, P.E. Hopkins & M. Karppinen, Thermal conductivity reduction at inorganic-organic interfaces: from regular superlattices to irregular gradient layer sequences, *Adv. Mater. Interfaces* **5**, 1701692 (2018).

# THERMOELECTRIC MODULE

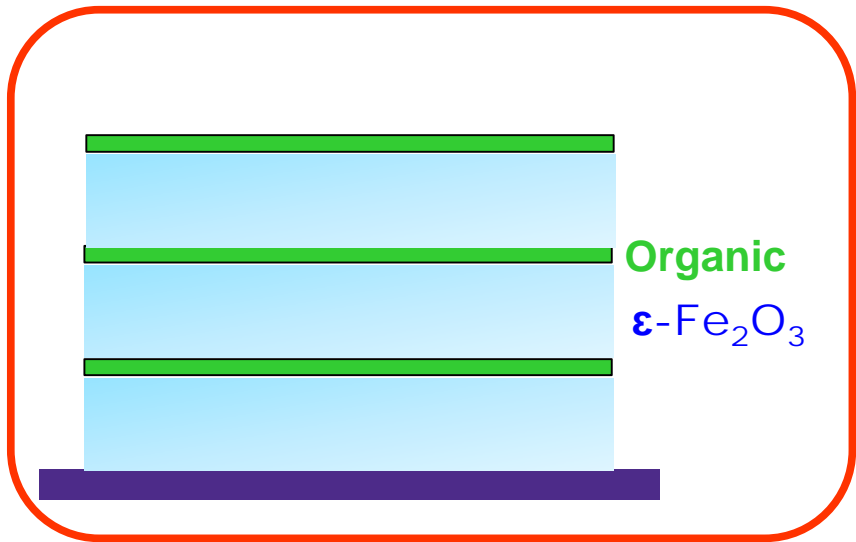
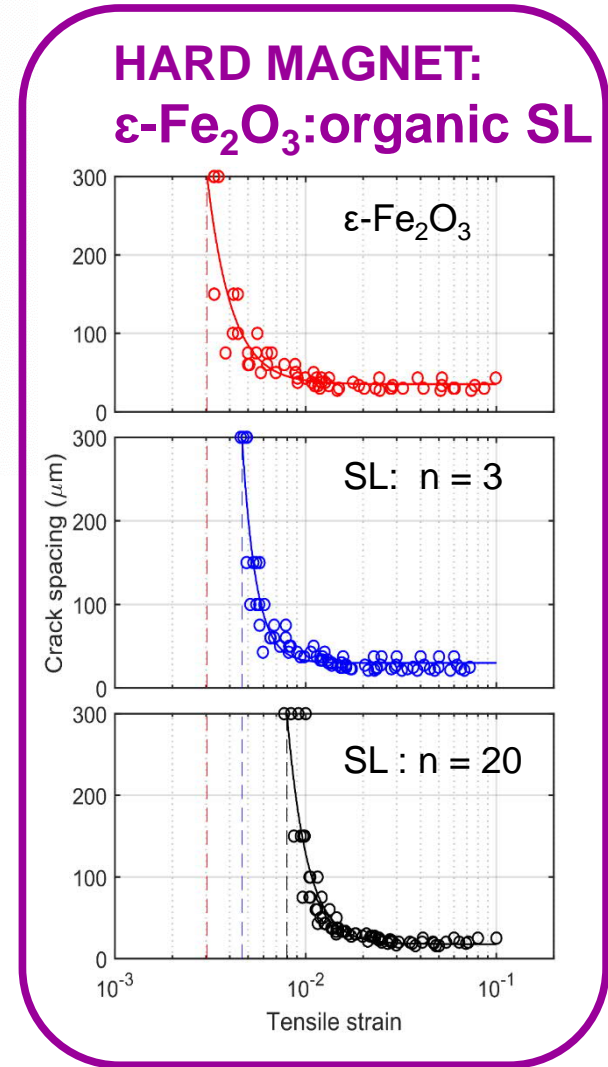
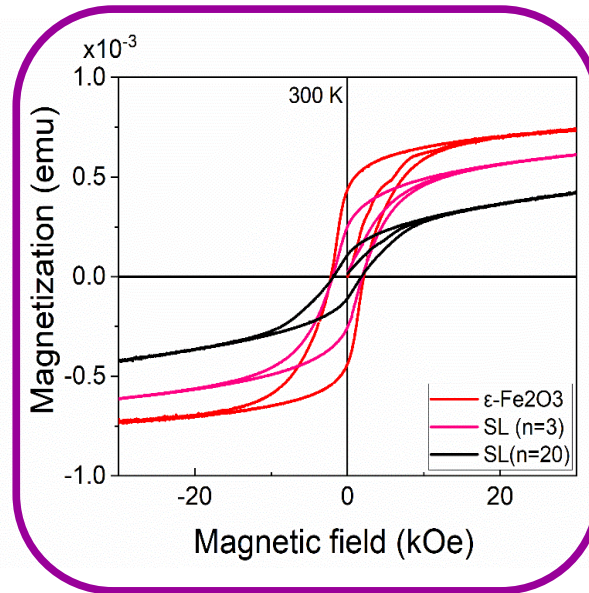
## Silicon



## Plastics



**FLEXIBLE RT  
MAGNETIC films**  
 $\epsilon\text{-Fe}_2\text{O}_3$ :organic



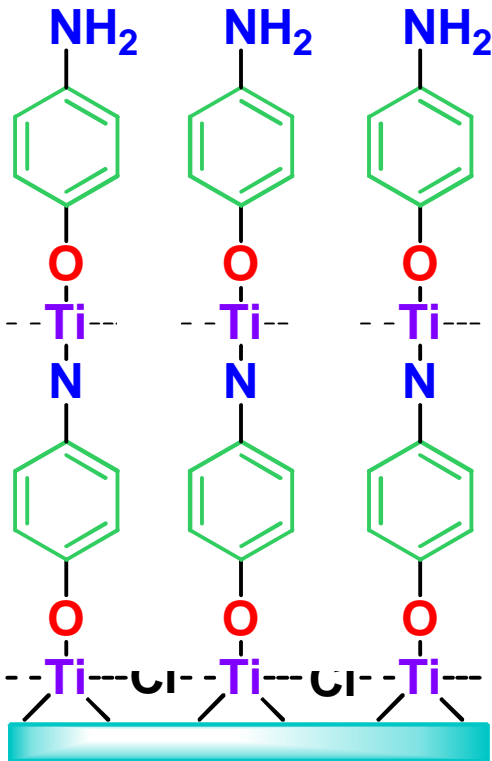
A. Philip, J.-P. Niemelä, G.C. Tewari, B. Putz, T.E.J. Edwards, M. Itoh, I. Utke & M. Karppinen, Flexible  $\epsilon\text{-Fe}_2\text{O}_3$ -terephthalate thin-film magnets through ALD/MLD, *ACS Applied Materials & Interfaces* **12**, 21912 (2020).



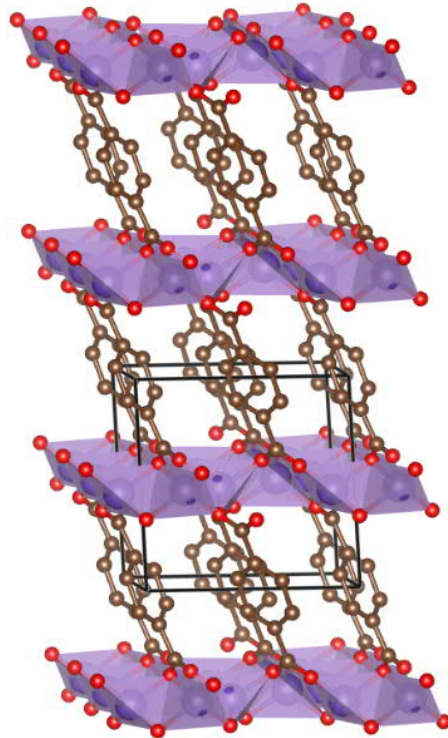
# About the CHEMICAL BONDING in the films

- Covalent bonds
- Ionic bonds
- Hydrogen bonds

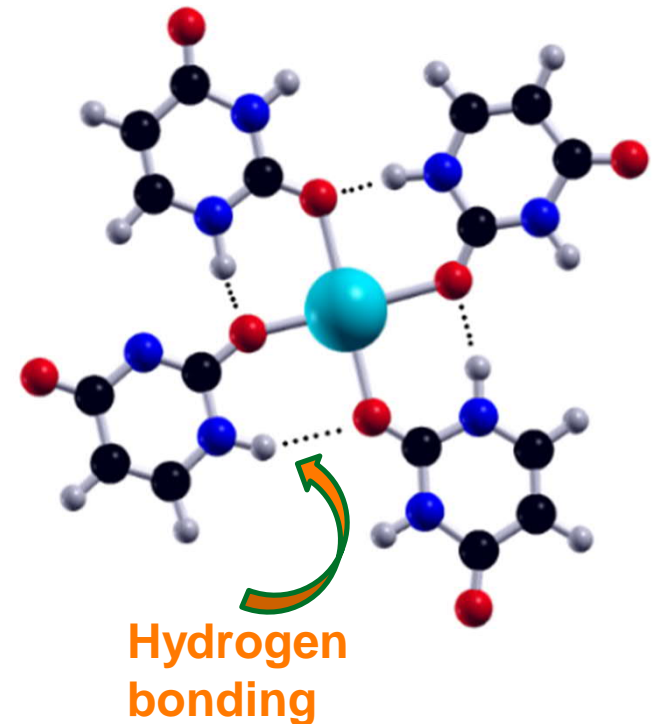
Ti + AP

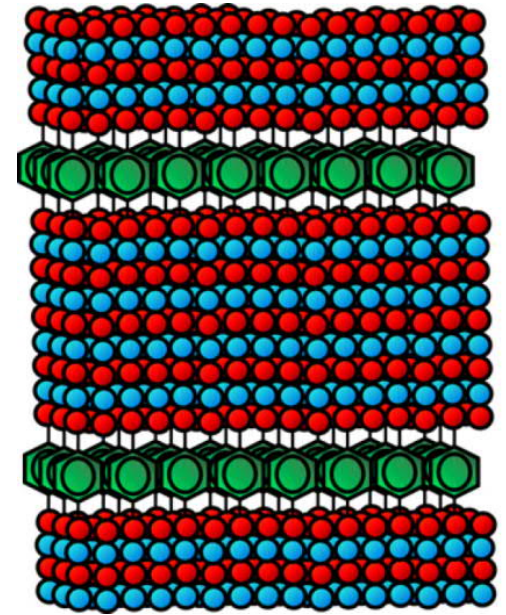
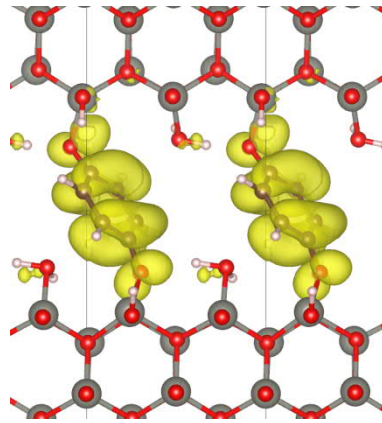
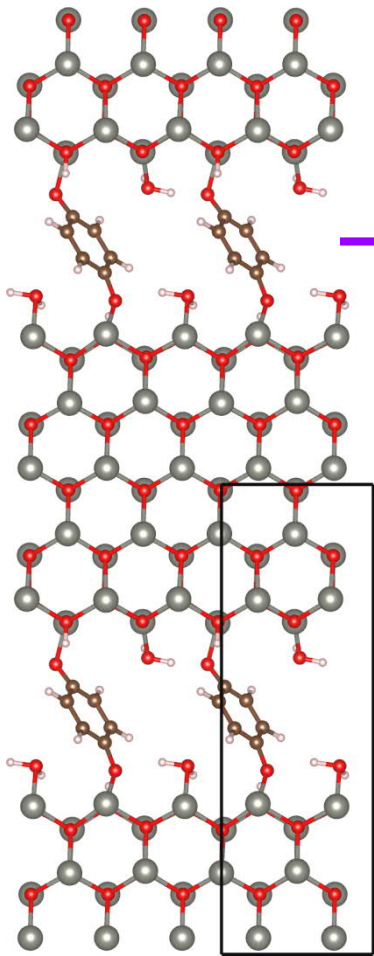


Li + TPA



Na + Uracil





# MODELLING

- **Computational** first-principles calculations
- **Atomic-level bonding models**
- **Band structures**
- **Prediction of physical properties**

**A.J. Karttunen**, T. Tynell & M. Karppinen, *J. Phys. Chem. C* 119, 13105 (2015).